

Status of the **H_vLMES** neutrino mass experiment

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on behalf of the HOLMES collaboration

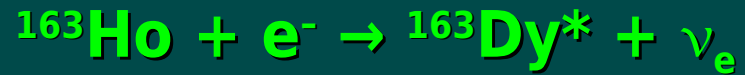
Università di Milano-Bicocca e INFN - Sezione di Milano-Bicocca





- ^{163}Ho decay calorimetry and neutrino mass measurement
- HOLMES experiment goal and design
- HOLMES tasks status
 - isotope production and chemical purification
 - isotope mass separation and embedding
 - single detector design
 - detector read-out and DAQ
 - detector array fabrication
- conclusions and perspectives

Electron capture calorimetric experiments

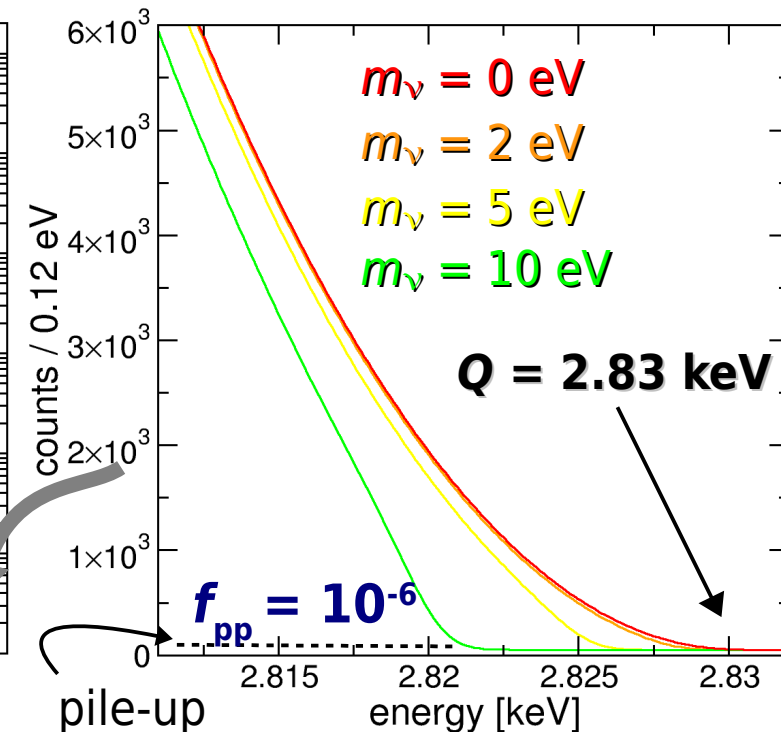
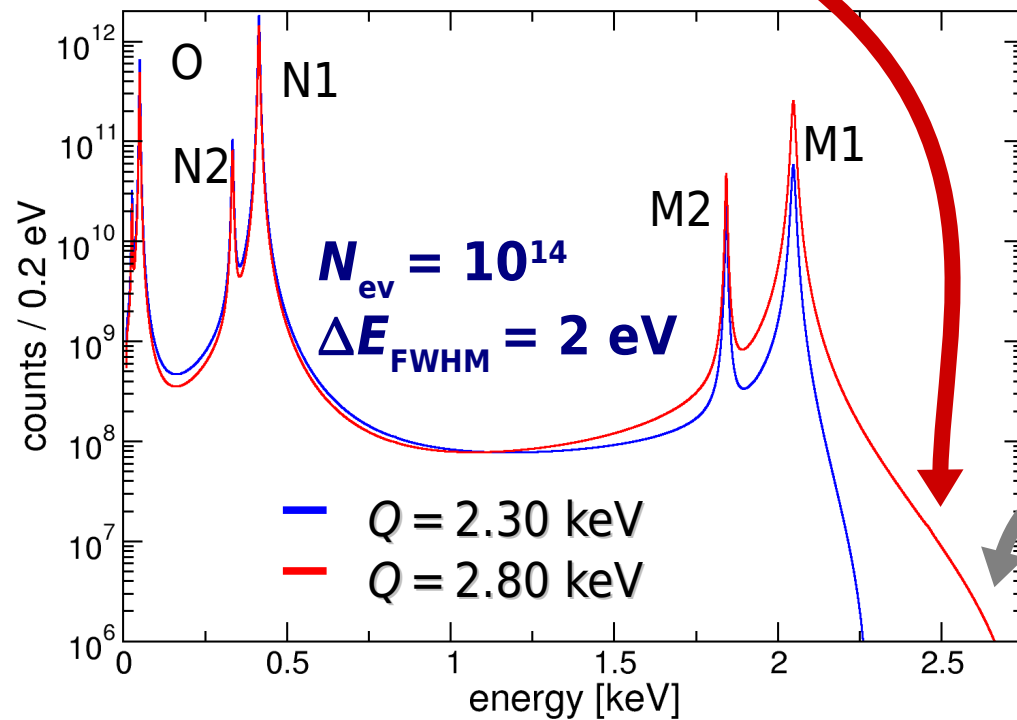


electron capture from shell \geq M1

A. De Rújula and M. Lusignoli, Phys. Lett. B 118 (1982) 429

- calorimetric measurement of Dy atomic de-excitations (mostly non-radiative)
- $Q = 2.83$ keV (determined with Penning trap in 2015)
 - ▶ end-point rate and ν mass sensitivity depend on $Q - E_{M1}$
- $\tau_{1/2} \approx 4570$ years $\rightarrow 2 \times 10^{11}$ ^{163}Ho nuclei \leftrightarrow 1Bq

$$N(E_c) = \frac{G_\beta^2}{4\pi^2} (Q - E_c) \sqrt{(Q - E_c)^2 - m_\nu^2} \times \sum_i n_i C_i \beta_i^2 B_i \frac{\Gamma_i}{2\pi} \frac{1}{(E_c - E_i)^2 + \Gamma_i^2/4}$$



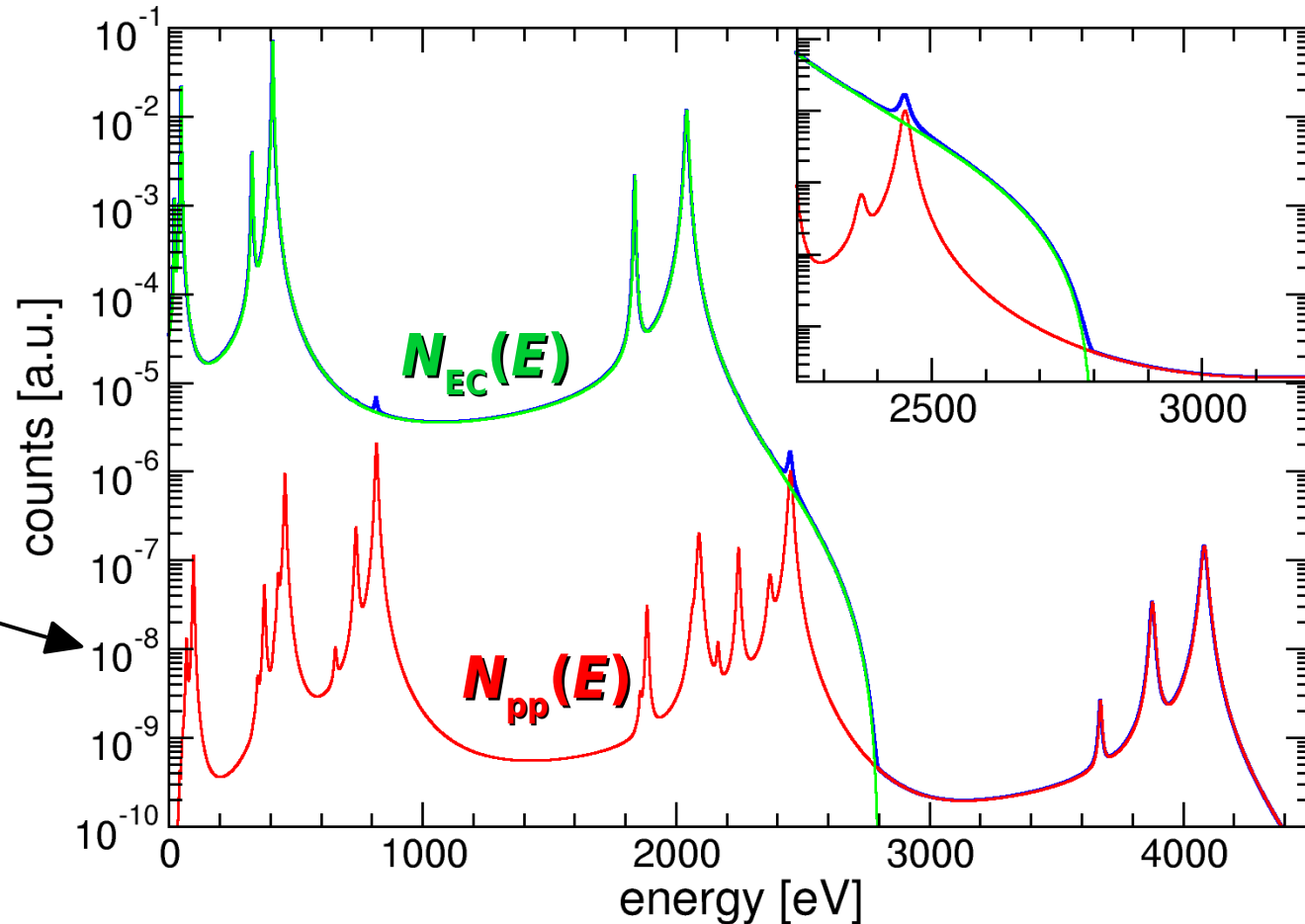
Electron capture calorimetric experiments



- calorimetric measurement \leftrightarrow **detector speed is critical**
- accidental coincidences \rightarrow complex pile-up spectrum

► $N_{pp}(E) = f_{pp} N_{EC}(E) \otimes N_{EC}(E)$ with $f_{pp} \approx A_{EC} \tau_R$

A_{EC} EC activity per detector
 τ_R time resolution (\approx rise time)



$Q = 2800 \text{ eV}$

$f_{pp} = 10^{-4}$

$N_{EC}(E)$ without higher order processes (shake up / shake off)

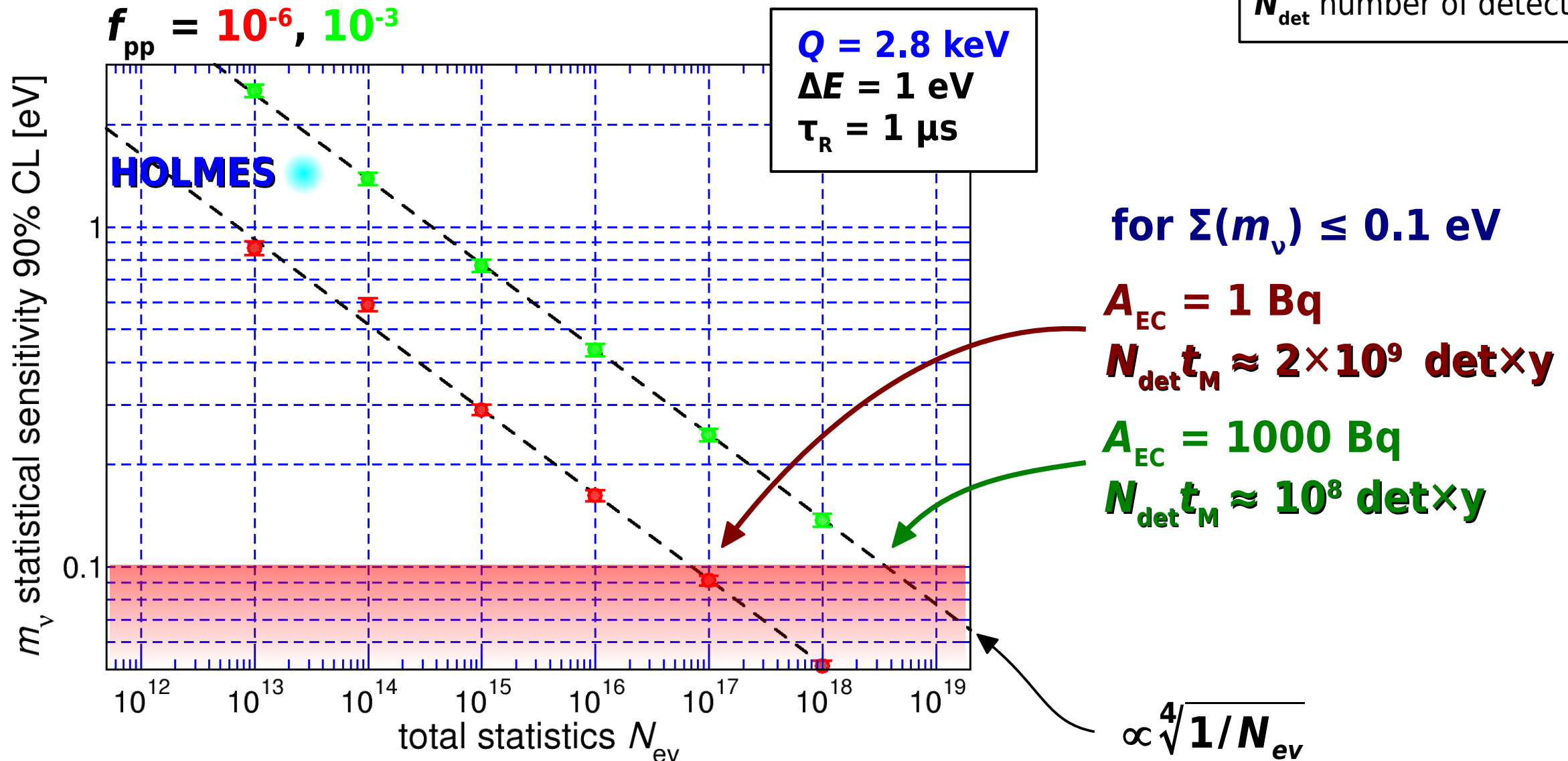
Montecarlo simulations: ^{163}Ho sensitivity potential



m_ν sensitivity mostly depends on: \blacktriangle total statistics $N_{\text{ev}} = A_{\text{EC}} N_{\text{det}} t_{\text{M}}$

\blacktriangledown pile fraction $f_{\text{pp}} = A_{\text{EC}} \tau_{\text{R}}$

t_{M} measuring time
 N_{det} number of detectors



goal

- direct neutrino mass measurement: m_ν **statistical sensitivity around 1 eV**
- prove potential and scalability:
 - ▶ assess EC spectral shape
 - ▶ assess systematic errors

baseline

- **low T microcalorimeters**
with **implanted ^{163}Ho**

▶ 6.5×10^{13} atom/det $\rightarrow A_{\text{EC}} = 300$ c/s/det

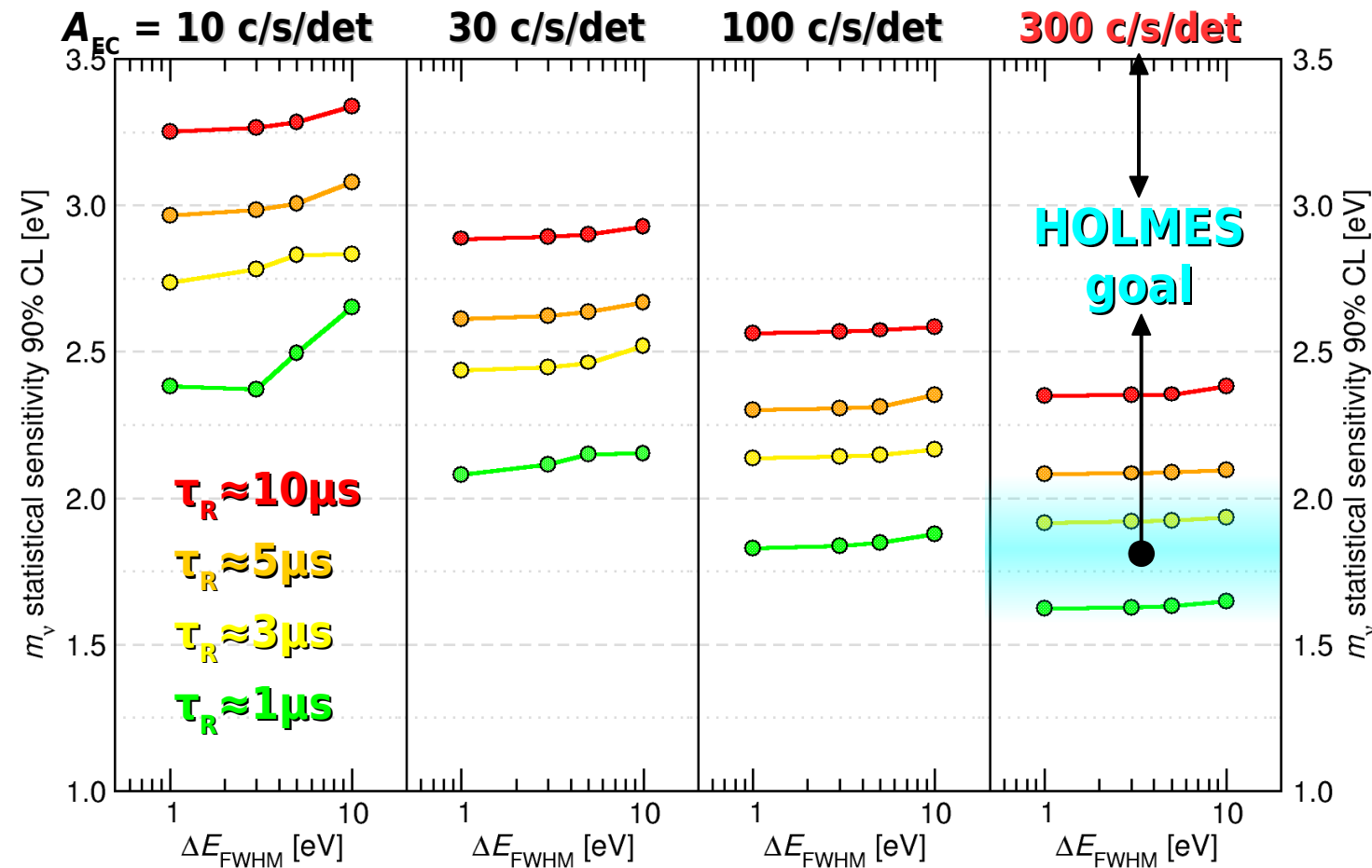
▶ $\Delta E \approx 1$ eV and $\tau_R \approx 1 \mu\text{s}$

- **1000 channel array**

▶ 6.5×10^{16} ^{163}Ho nuclei $\rightarrow \approx 18 \mu\text{g}$

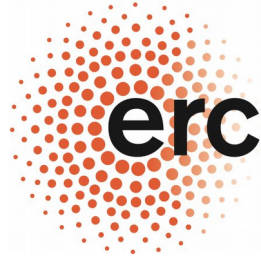
▶ 3×10^{13} events in **3 years**

exposure $N_{\text{det}} t_M = 1000 \text{ det} \times 3 \text{ y}$



5 years project started on February 1st 2014 (now extended by 1 year)

HOLMES collaboration



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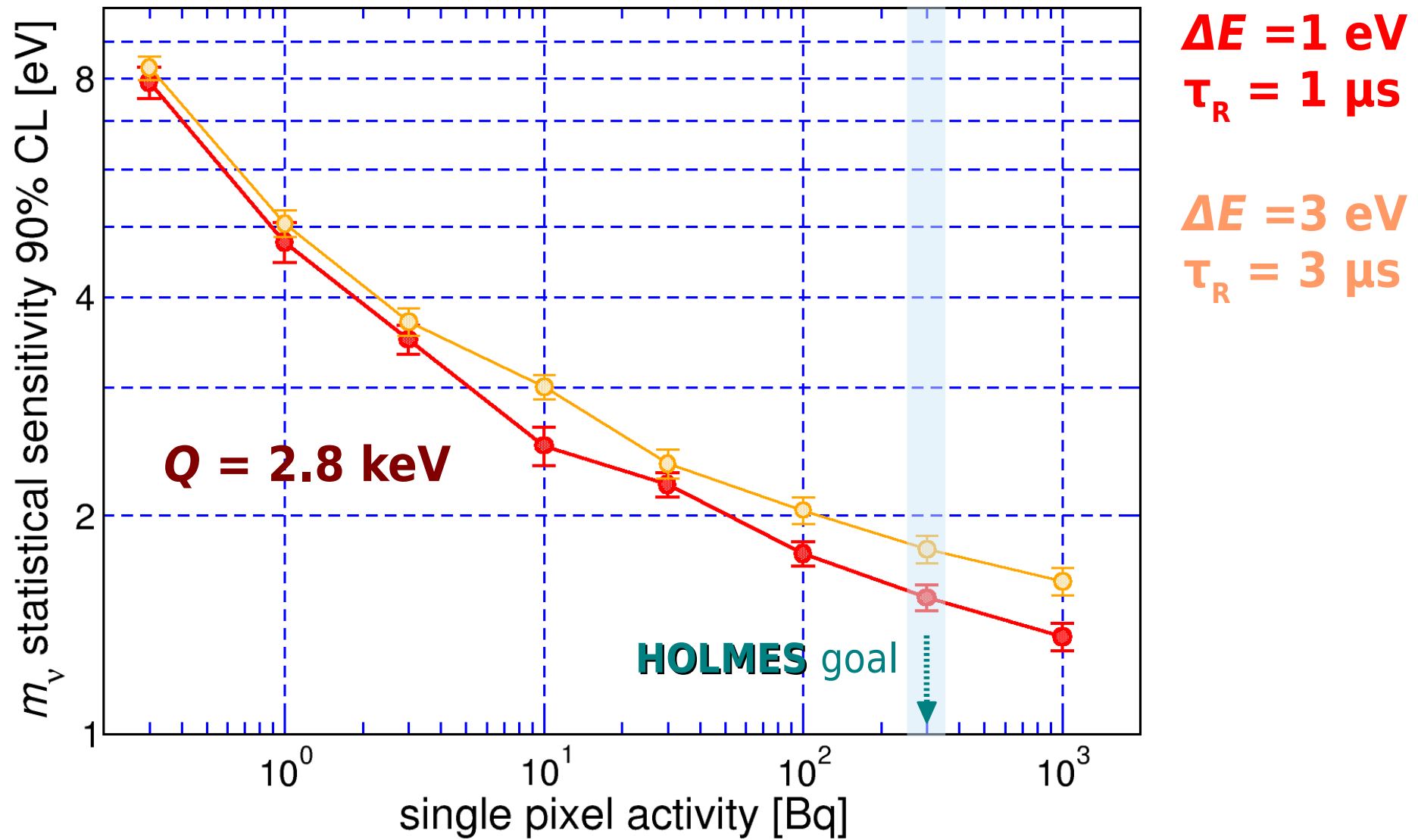
U.Koester

<http://artico.mib.infn.it/holmes>

Statistical sensitivity and single pixel activity



exposure $N_{\text{det}} t_M = 1000 \text{ det} \times 3 \text{ y}$



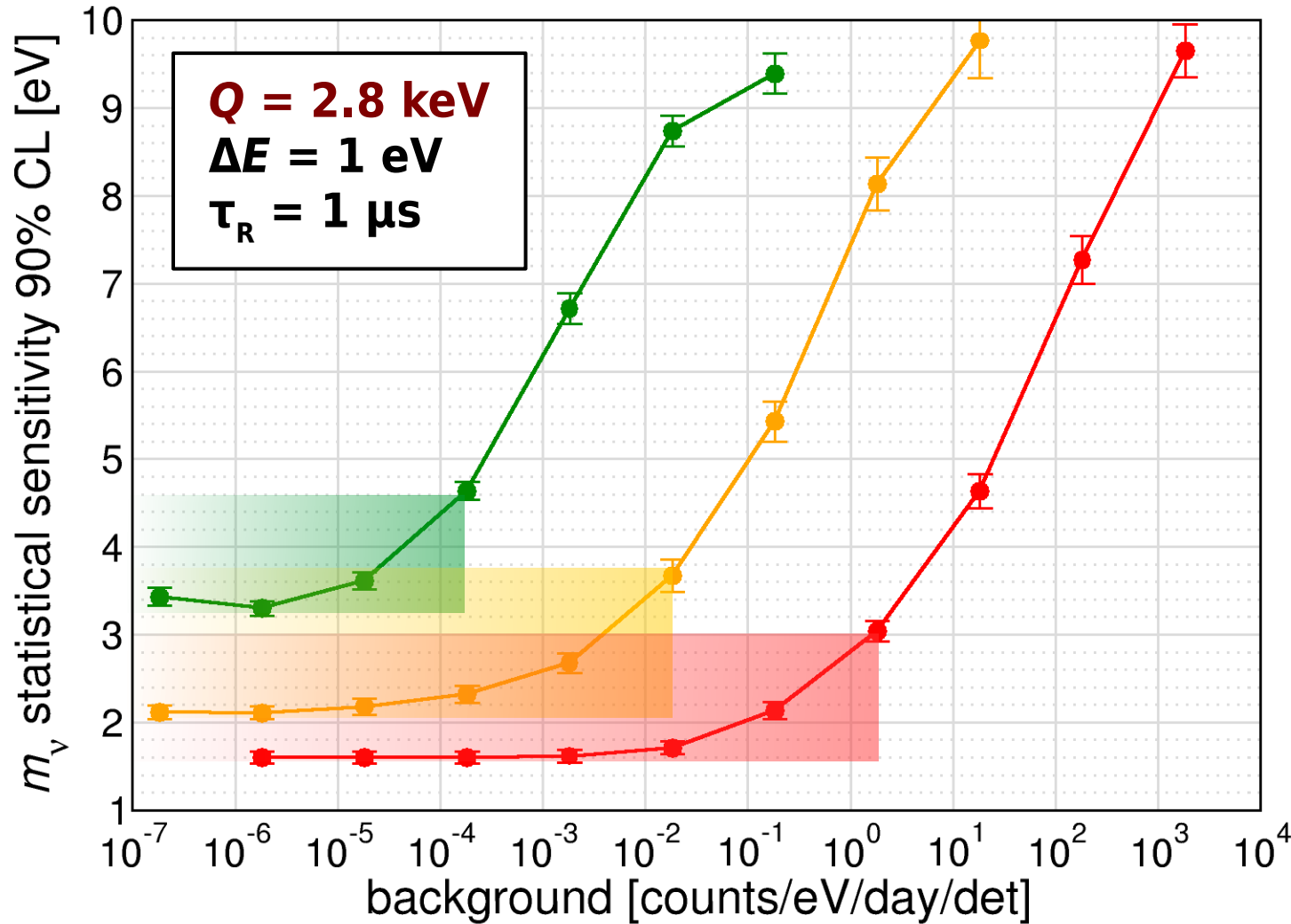
high activity \rightarrow robustness against (flat) background

$A_{\text{EC}} = 300 \text{ Bq} \rightarrow \text{bkg} < \approx 0.1 \text{ counts/eV/day/det}$

Effect of background on sensitivity



exposure $N_{\text{det}} t_M = 1000 \text{ det} \times 3 \text{ y}$



$A_{\text{EC}} = 3 \text{ Bq/det}$

$f_{\text{pp}} = 3 \times 10^{-6}$

$A_{\text{EC}} = 30 \text{ Bq/det}$

$f_{\text{pp}} = 3 \times 10^{-5}$

$A_{\text{EC}} = 300 \text{ Bq/det}$

$f_{\text{pp}} = 3 \times 10^{-4}$

pile-up background \approx average rate $\langle r_{\text{pp}} \rangle$

$$\langle r_{\text{pp}} \rangle = A_{\text{EC}} f_{\text{pp}} / 2Q = \mathbf{1.5 \times 10^{-4}} \quad \mathbf{1.5 \times 10^{-2}} \quad \mathbf{1.5} \text{ c/eV/day/det}$$

Low energy background

- environmental γ radiation
 - γ , X and β from close surroundings
 - cosmic rays
- ▷ GEANT4 → **$bkg \approx 5 \times 10^{-5}$ c/eV/day/det (0 - 4 keV)**

HOLMES target

for $A_{EC} = 300$ Bq

$bkg < \approx 0.1$ c/eV/day/det

Au pixel $200 \times 200 \times 2 \mu\text{m}^3$



MIBETA experiment: $300 \times 300 \times 150 \mu\text{m}^3$ AgReO₄ crystals at sea level
 $bkg(2-5\text{keV}) \approx 1.5 \times 10^{-4}$ c/eV/day/det

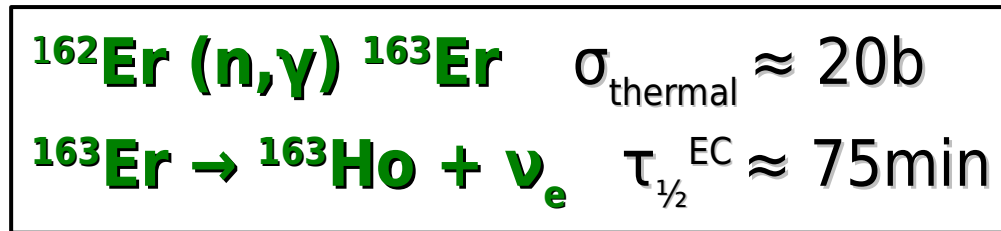
• internal radionuclides

- ▷ **$^{166\text{m}}\text{Ho}$** (β^- , $Q = 1.8$ MeV, $\tau_{1/2} = 1200$ y, produced along with ^{163}Ho)
- ▷ GEANT4 → **$bkg \approx 0.5$ c/eV/day/det/Bq($^{166\text{m}}\text{Ho}$)**
- ▷ **$A(^{163}\text{Ho}) = 300$ Bq/det** ($\leftrightarrow \approx 6.5 \times 10^{13}$ nuclei/det)

$bkg(^{166\text{m}}\text{Ho}) < 0.1$ c/eV/day/det → $A(^{163}\text{Ho})/A(^{166\text{m}}\text{Ho}) > 1500$

→ $N(^{163}\text{Ho})/N(^{166\text{m}}\text{Ho}) > 6000$

^{163}Ho production by neutron activation



Tm 163 1.81 h ϵ β^+ ... γ 104; 69; 241; 1434; 1397...	Tm 164 5.1 m 2.0 m ϵ β^+ 2.9... γ 208; 315...	Tm 165 30.06 h ϵ β^+ ... γ 243; 47; 297; 807...	Tm 166 7.70 h ϵ β^+ 1.9... γ 779; 2052; 184; 1274...	Tm 167 9.25 d ϵ γ 532... m	Tm 168 93.1 d ϵ ; β^+ ... β^- ... γ 198; 816; 447...
Er 162 0.139 σ 19 $\sigma_n, \alpha < 0.011$	Er 163 75 m ϵ β^+ ... γ (1114...) g	Er 164 1.601 σ 13 $\sigma_n, \alpha < 0.0012$	Er 165 10.3 h ϵ no γ	Er 166 33.503 σ 3 + 14 $\sigma_n, \alpha < 7\text{E-}5$	Er 167 2.3 s 22.869 γ 208 σ 650 $\sigma_n, \alpha < 3\text{E-}6$
Ho 161 6.7 s 2.5 h ϵ γ 26; 78... e^- γ 211	Ho 162 68 m 15 m ϵ β^+ 1.1... γ 185; 1220; 283; 937... e^-	Ho 163 1.1 4570 a ϵ no γ	Ho 164 37 m 29 m ϵ β^- 1.0... γ 91; 73... e^-	Ho 165 100 σ 3.1 + 58 $\sigma_n, \alpha < 2\text{E-}5$	Ho 166 1200 a 26.80 h β^- γ 184; 810; 712 σ 3100 e^-
Dy 160 2.329 σ 60 $\sigma_n, \alpha < 0.0003$	Dy 161 18.889 σ 600 $\sigma_n, \alpha < 1\text{E-}6$	Dy 162 25.475 σ 170	Dy 163 24.896 σ 120 $\sigma_n, \alpha < 2\text{E-}5$	Dy 164 28.260 σ 1610 + 1040	Dy 165 1.3 m 2.35 h γ 108; e^- β^- 0.9; 1.3... 1.0... γ 95; (362...) σ 2000 σ 3500

- HOLMES needs ≈ 200 MBq of ^{163}Ho**

with *reasonable* assumptions on the (unknown) global embedding process efficiency...

- ^{162}Er irradiation at **ILL nuclear reactor** (Grenoble, France)

- thermal neutron flux at **ILL**: 1.3×10^{15} n/cm²/s

- burn up** $^{163}\text{Ho}(n,\gamma)^{164}\text{Ho}$: $\sigma_{\text{burn-up}} \approx 200\text{b}$ (preliminary result from **PSI** analysis)

- $^{165}\text{Ho}(n,\gamma)$ (mostly from $^{164}\text{Er}(n,\gamma)$) \rightarrow **$^{166\text{m}}\text{Ho}$** (β , $\tau_{1/2} = 1200\text{y}$) $\rightarrow A(^{163}\text{Ho})/A(^{166\text{m}}\text{Ho}) = 100 \sim 1000$

- chemical pre-purification and post-separation at **PSI** (Villigen, CH)

HOLMES source production



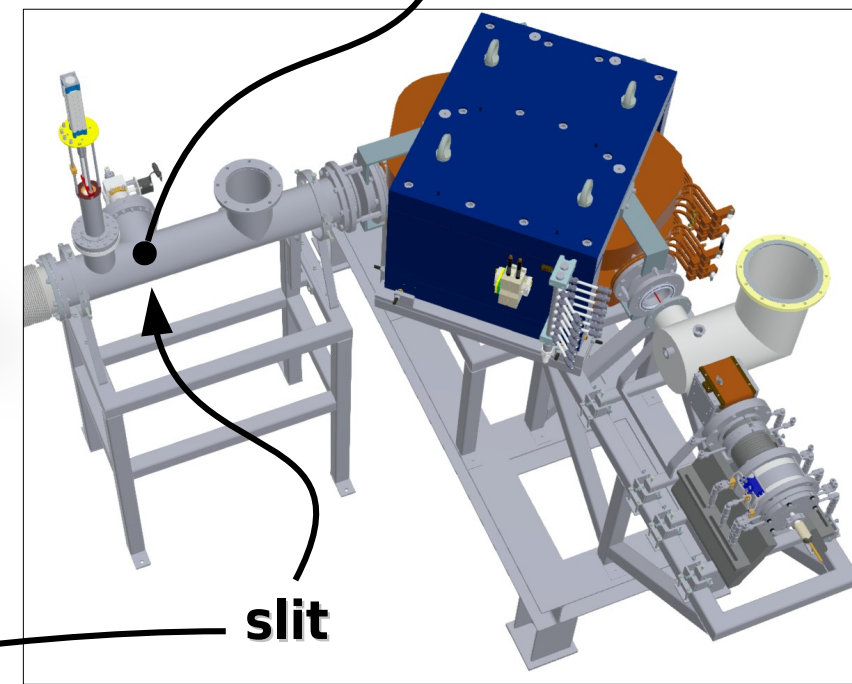
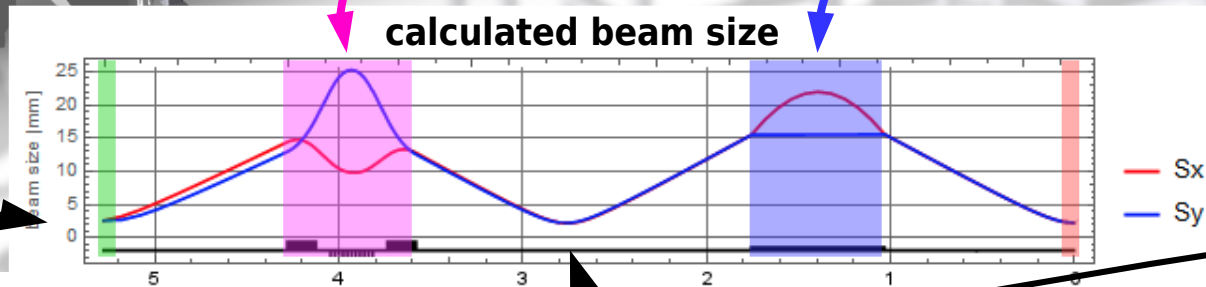
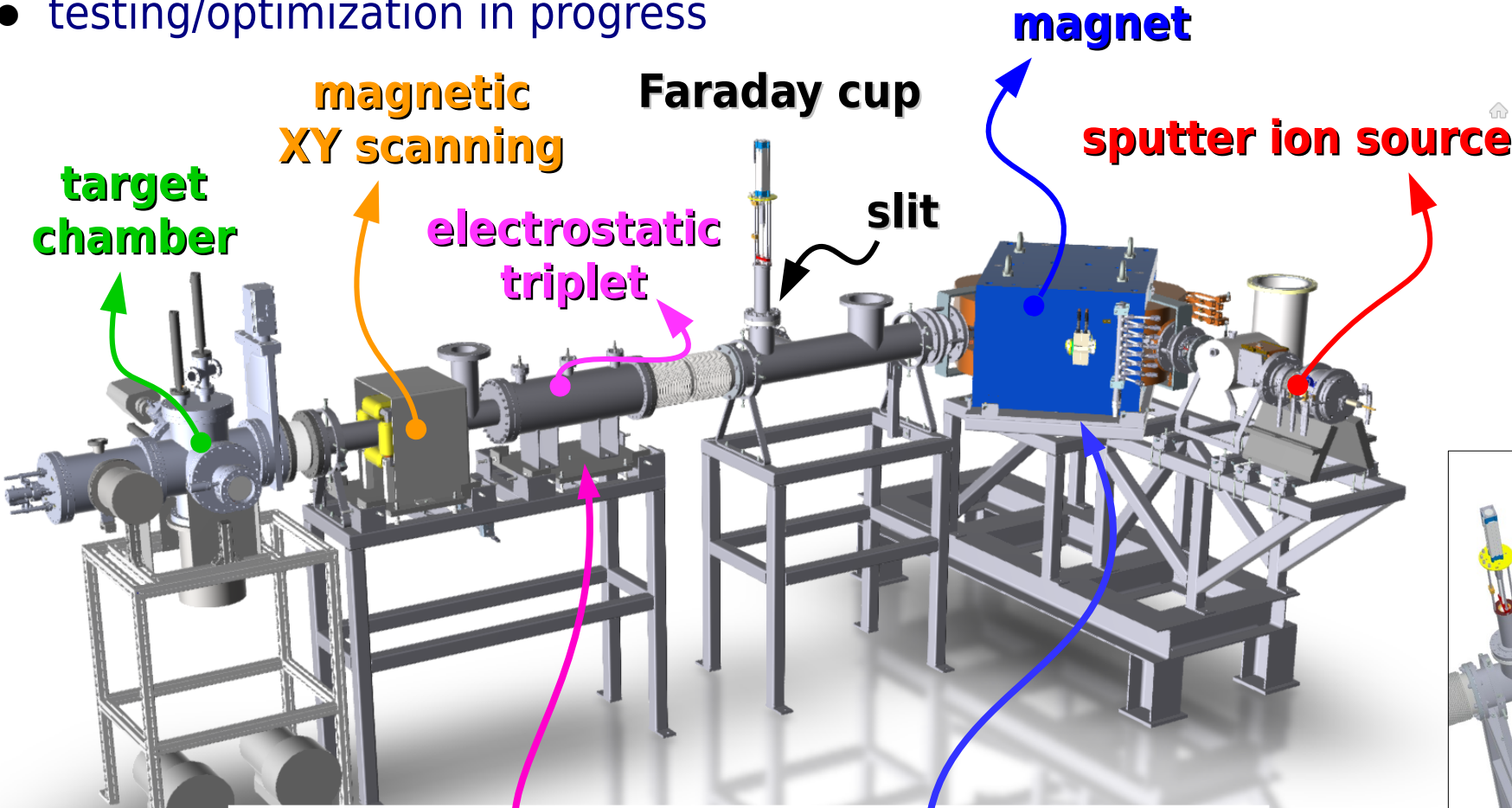
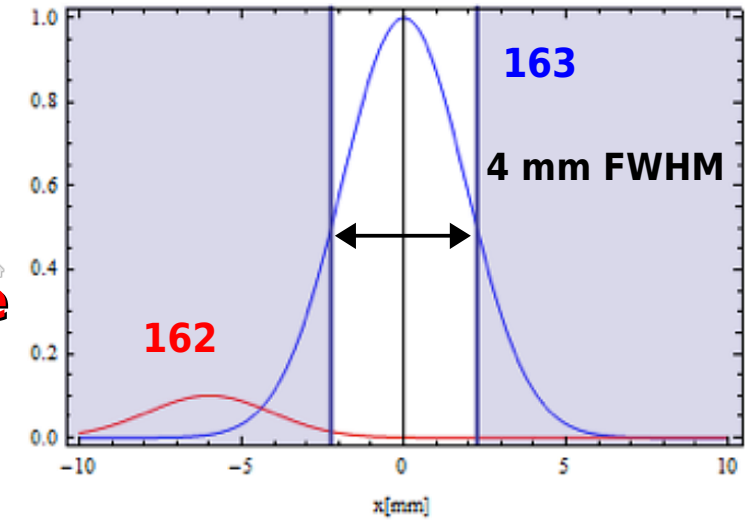
- **enriched Er_2O_3** samples irradiated at **ILL** and pre-/post-processed at **PSI**
 - ▶ 25 mg irradiated for 55 days (2014) → $A(^{163}\text{Ho}) \approx 5 \text{ MBq}$ ($A(^{166\text{m}}\text{Ho}) \approx 10 \text{ kBq}$)
 - ▶ 150 mg irradiated for 50 days (2015) → $A(^{163}\text{Ho}) \approx 23 \text{ MBq}$ ($A(^{166\text{m}}\text{Ho}) \approx 37 \text{ kBq}$)
- **Ho radiochemical separation** with ion-exchange resins in hot-cell at **PSI**
 - ▶ **efficiency $\geq 79\%$** (preliminary)
- **540 mg of 25% enriched Er_2O_3** irradiated 50 days at **ILL** in 2017 (separation in progress)
 - ▶ $A(^{163}\text{Ho})_{\text{theo}} \approx 100 \text{ MBq}$ (enough for R&D and 500 pixels) ($A(^{166\text{m}}\text{Ho}) \approx 180 \text{ kBq}$)



HOLMES mass separation and ion implantation



- extraction voltage 30-50 kV → 10-100 nm implant depth
- ^{163}Ho / $^{166\text{m}}\text{Ho}$ separation better than 10^5
- testing/optimization in progress



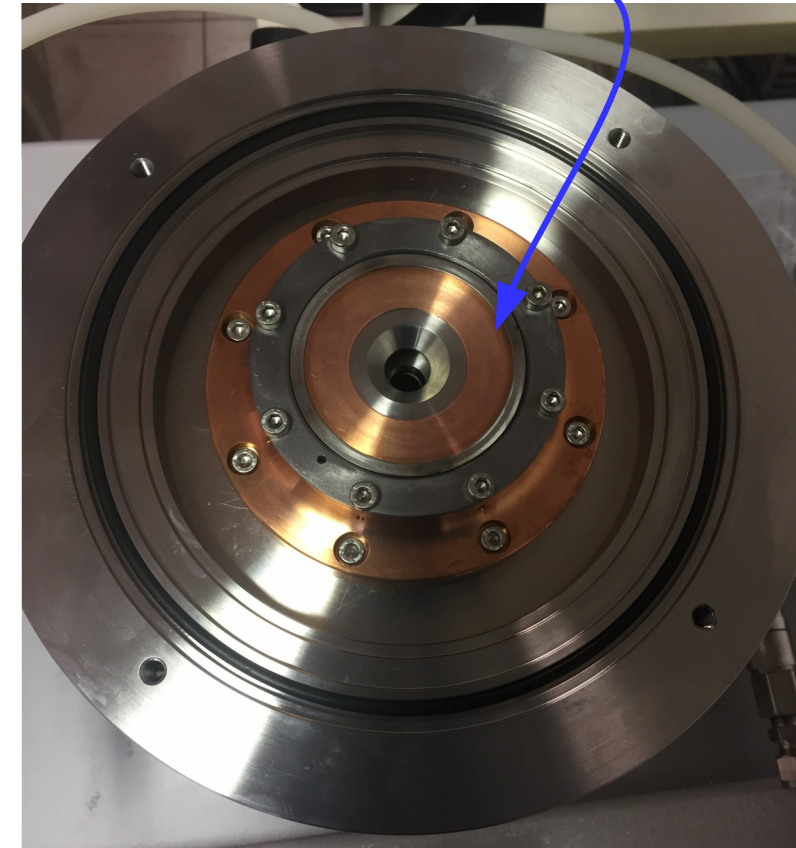
≈4 mm FWHM beam size

HOLMES ion implantation system testing



sputter ion source

sputter target

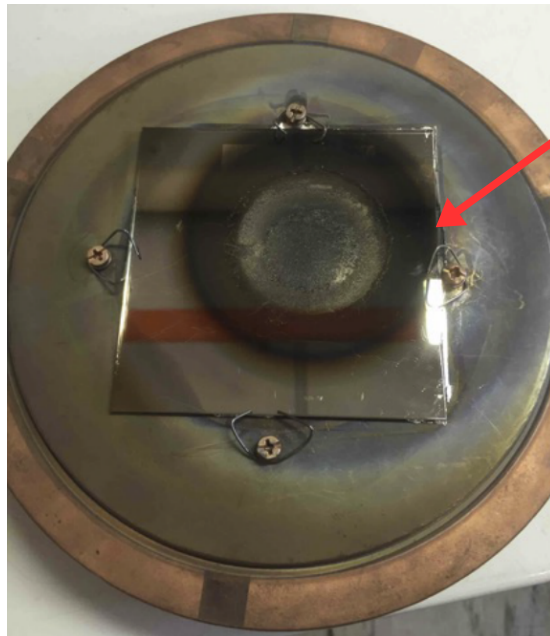


- tests in progress
 - ▶ without focussing
 - ▶ with natural Ho
- triplet and scanning stages ready to be installed

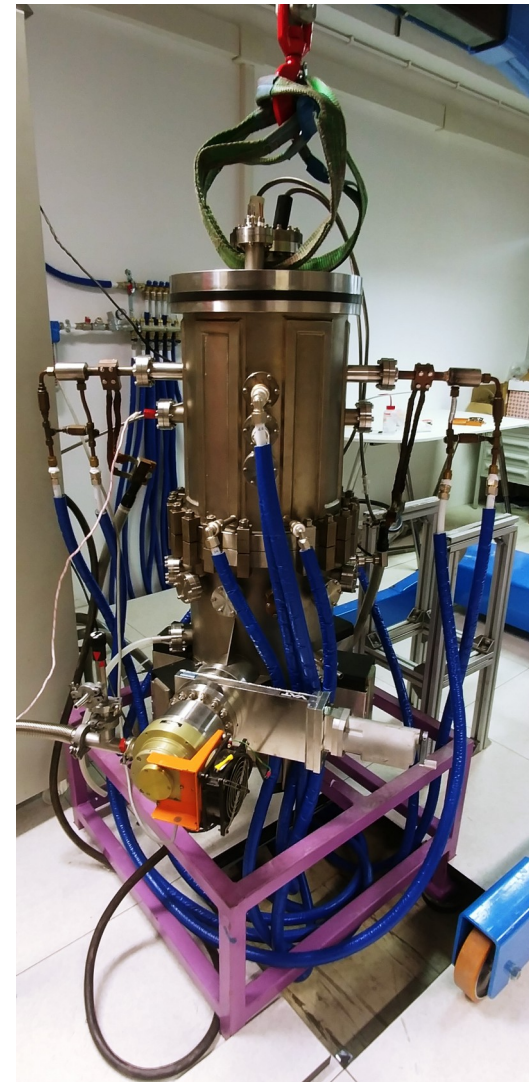
Ion source sputter target production / 1



- **metallic holmium sputter target** for implanter ion source
- enriched $\text{Er}_2\text{O}_3 \rightarrow \text{Ho}_2\text{O}_3$
- thermoreduction/distillation in furnace
 - ▶ **$\text{Ho}_2\text{O}_3 + 2\text{Y}(\text{met}) \rightarrow 2\text{Ho}(\text{met}) + \text{Y}_2\text{O}_3$ at $T > 1600^\circ\text{C}$**
- new furnace set-up in 2016
- work in progress to
 - ▶ optimize the process
 - ▶ measure efficiency ($\approx 70\%$, preliminary)



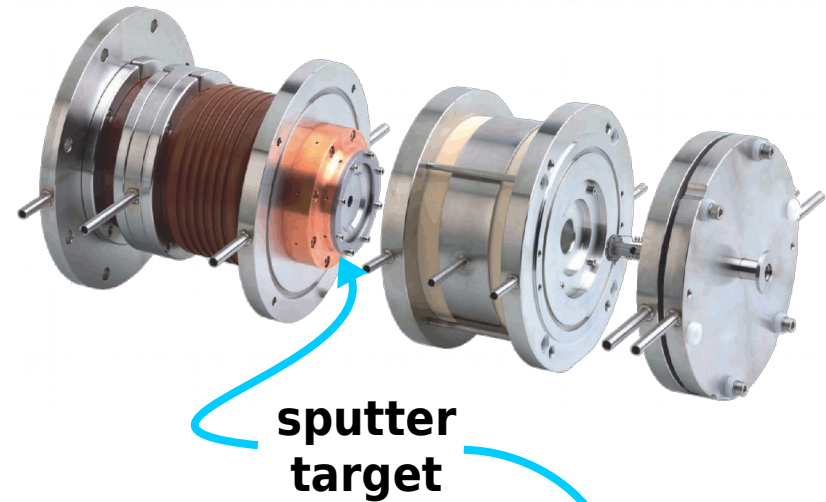
evaporated metallic holmium



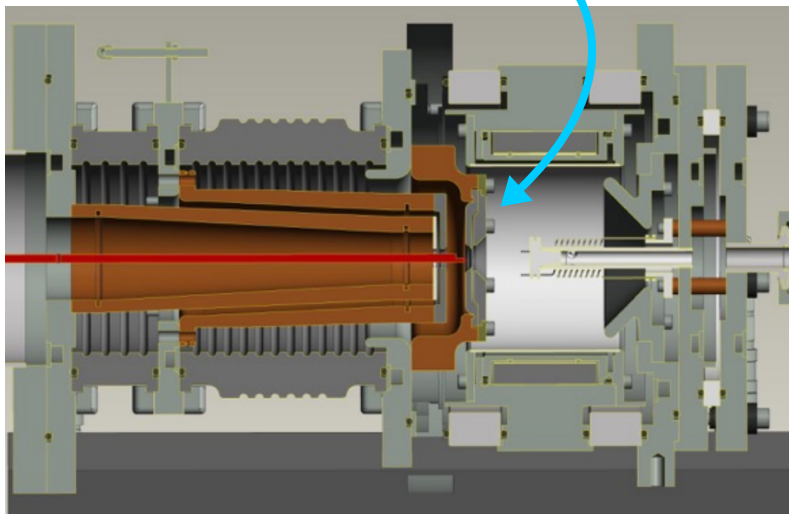
Ion source sputter target production / 2



- **metallic holmium sputter target** for implanter ion source
 - ▶ work is in progress to produce the sputter target
 - ▶ sintering Ho with other metals



sputter target



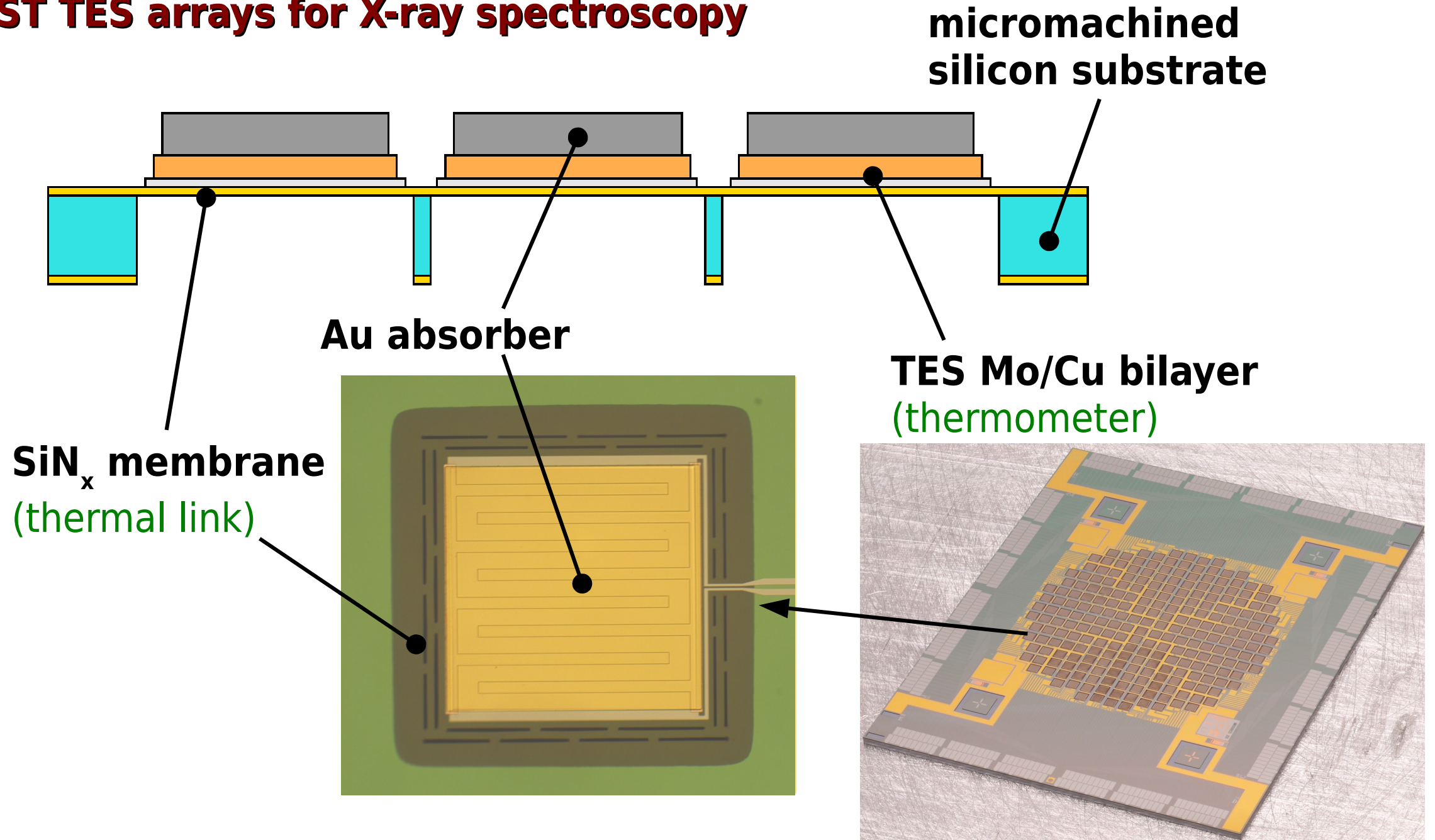
high pressure
+
heat treatment



TES low temperature microcalorimeters



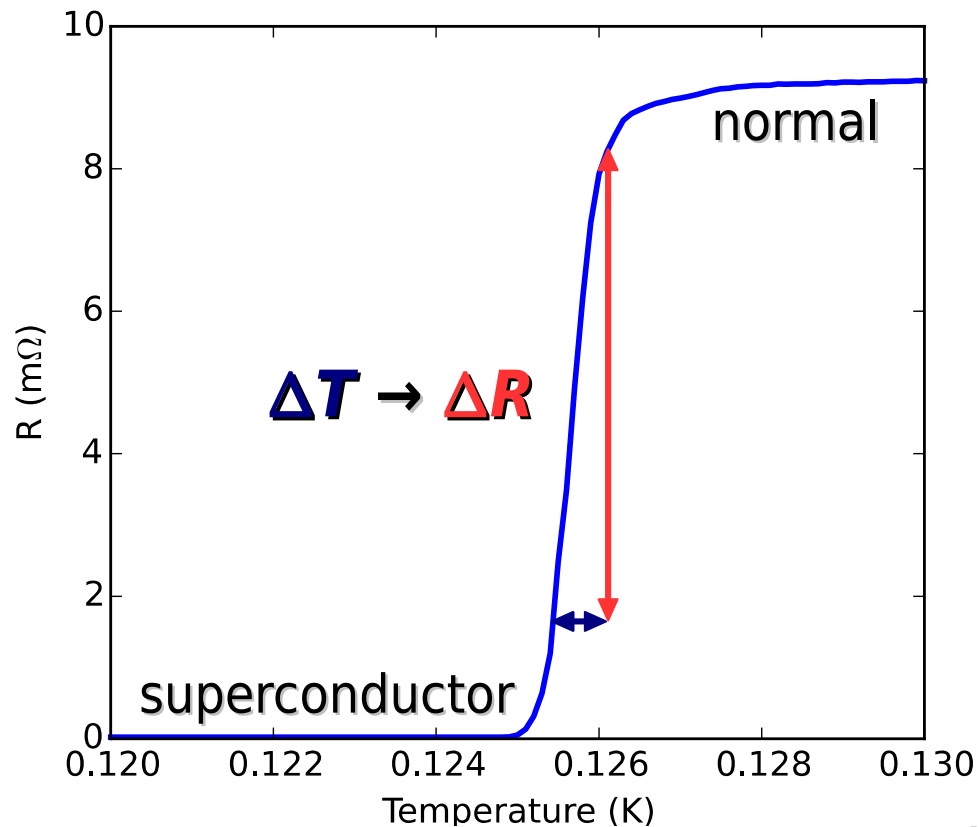
NIST TES arrays for X-ray spectroscopy



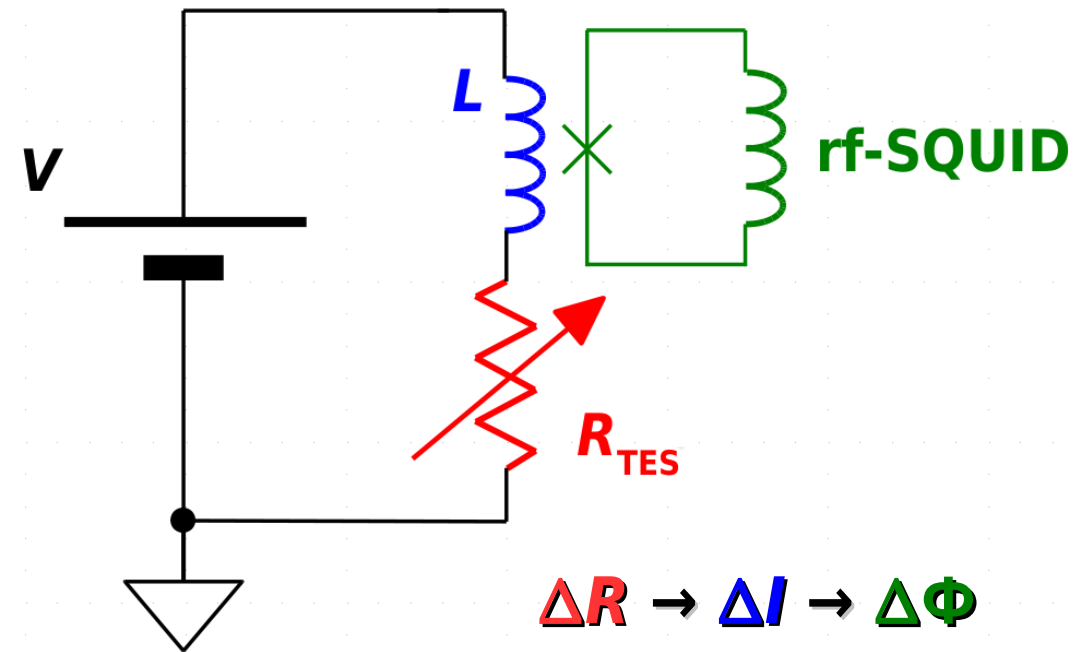
Superconducting transition edge sensors (TES)



- superconductor thin films operated inside the phase transition at T_c
 - ▶ metal-superconductor bilayers → tunable T_c (20÷200 mK) : Mo/Cu, Ti/Au, Ir/Au, ...
- high sensitivity $TdR/(RdT) \approx 100$ → **high energy resolution**
 - ▶ as thermal sensors → thermodynamical fluctuation limited → $\sigma_E^2 \approx \xi^2 k_B T^2 C$
- strong electron-phonon coupling → **high intrinsic speed**
- low impedance → SQUID read-out → **multiplexing for large arrays**



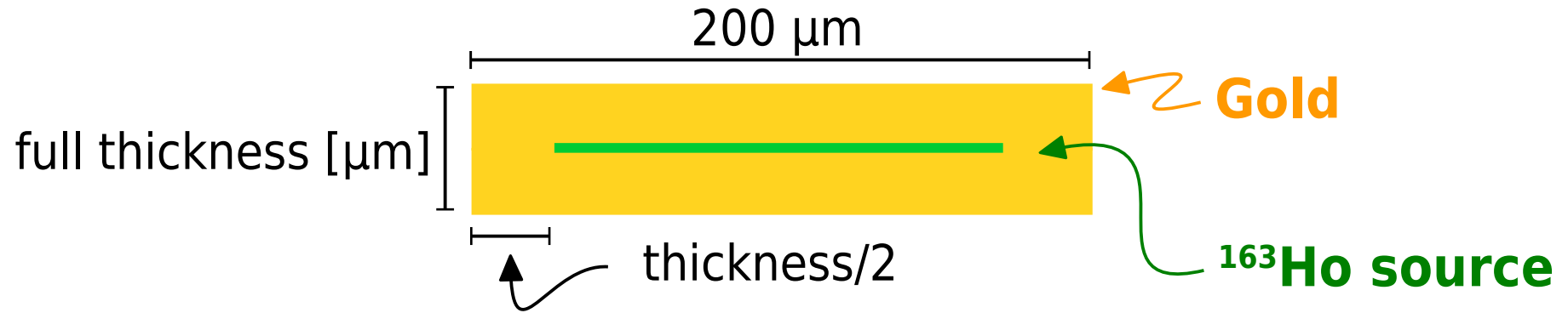
TES read-out: constant voltage bias



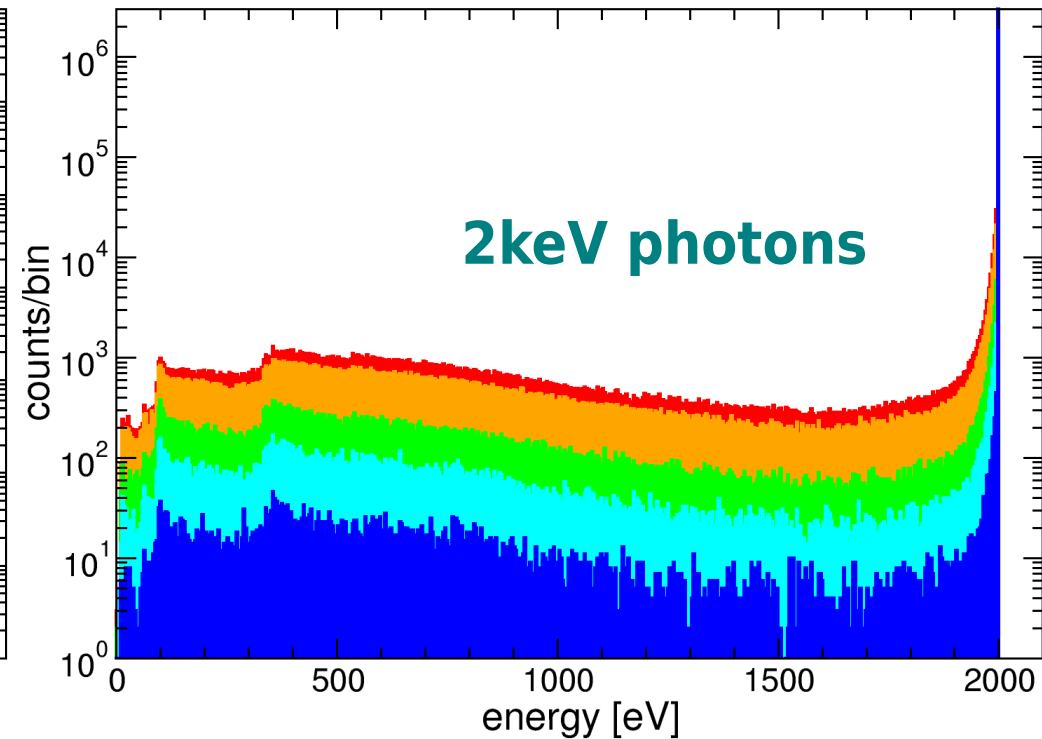
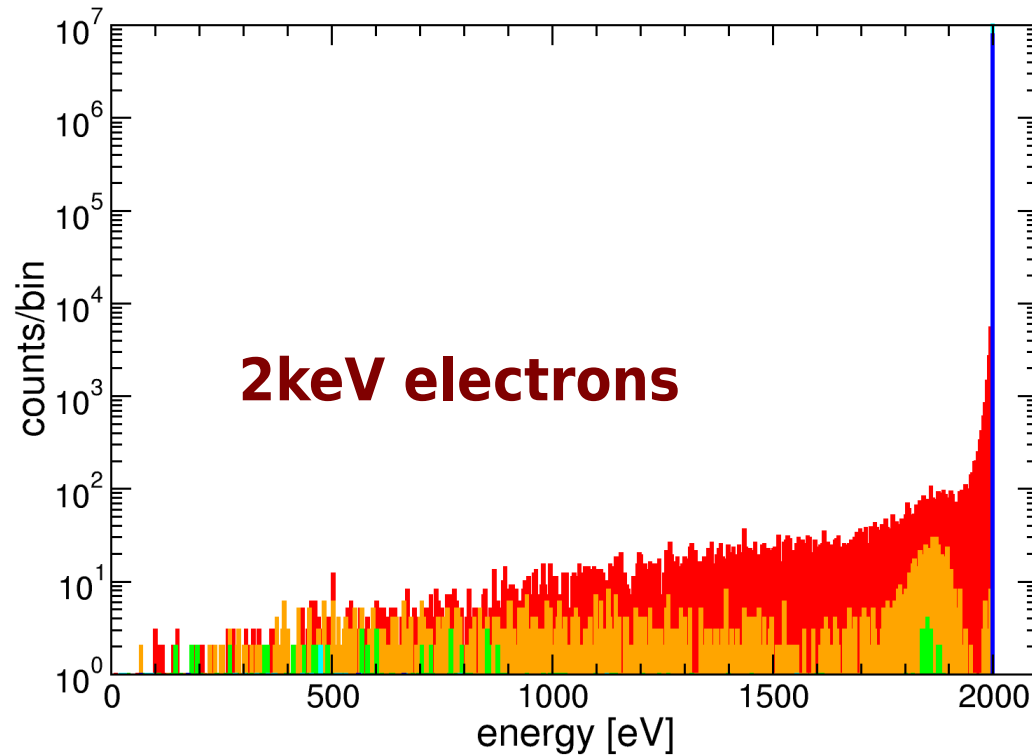
TES absorber design: stopping EC radiation / 1



Geant4 + LowEnergyEM MC simulation



full thickness: 0.05, 0.1, 0.5, 1, 2 μm

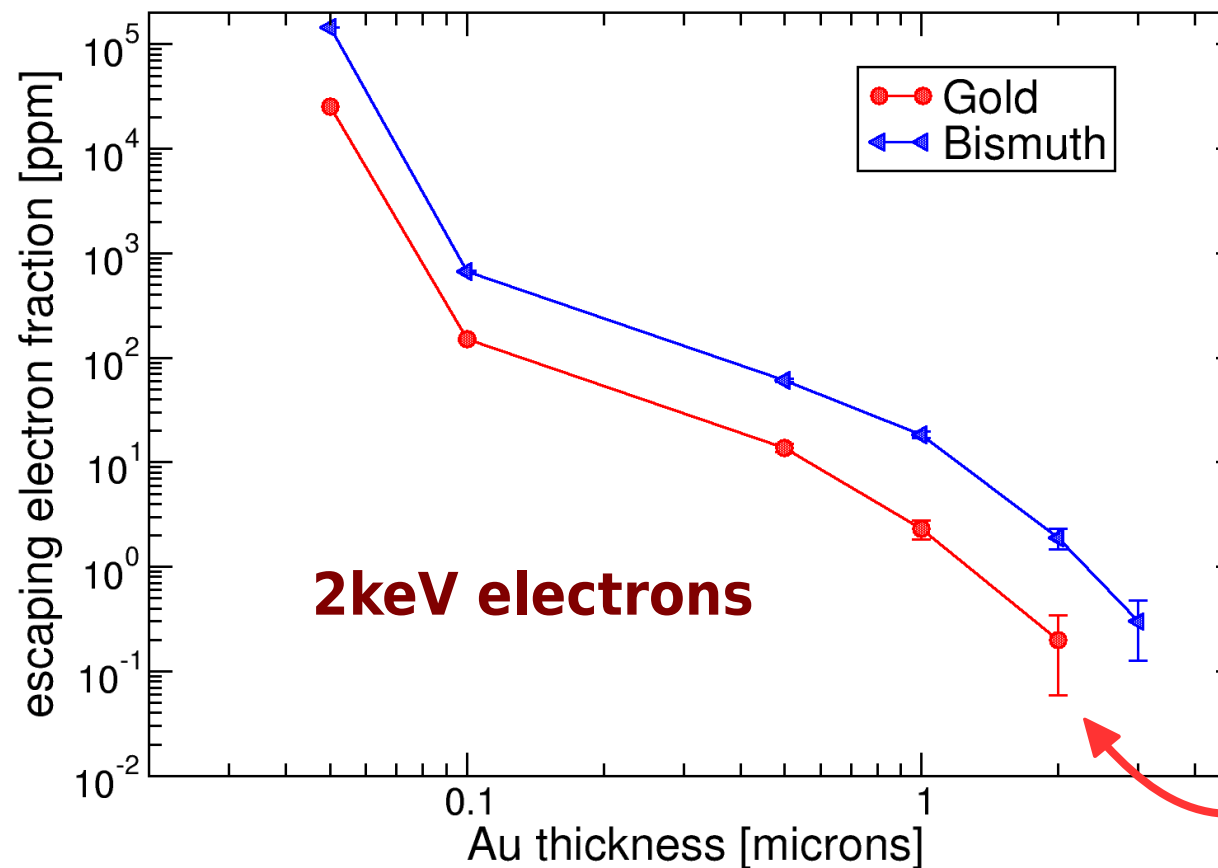
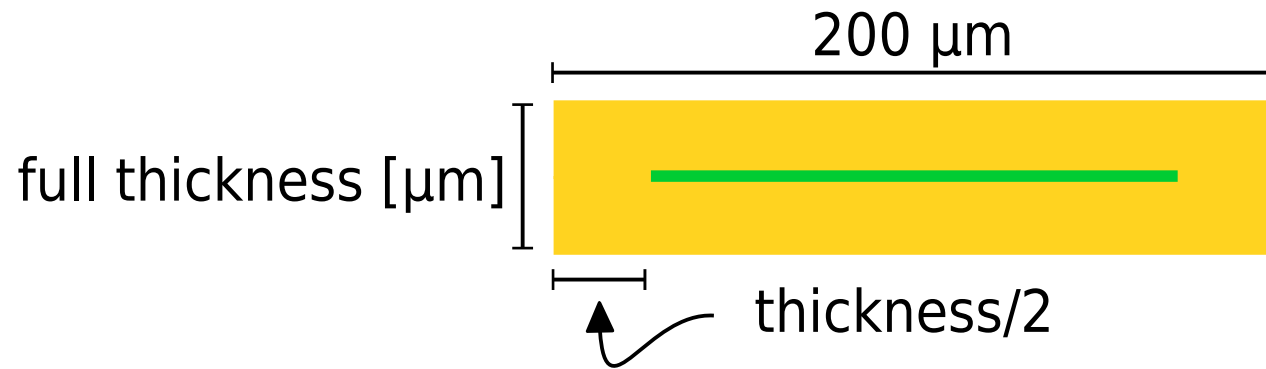


$$I_x \approx 10^{-5} I_e$$

TES absorber design: stopping EC radiation / 2



Geant4 + LowEnergyEM MC simulation

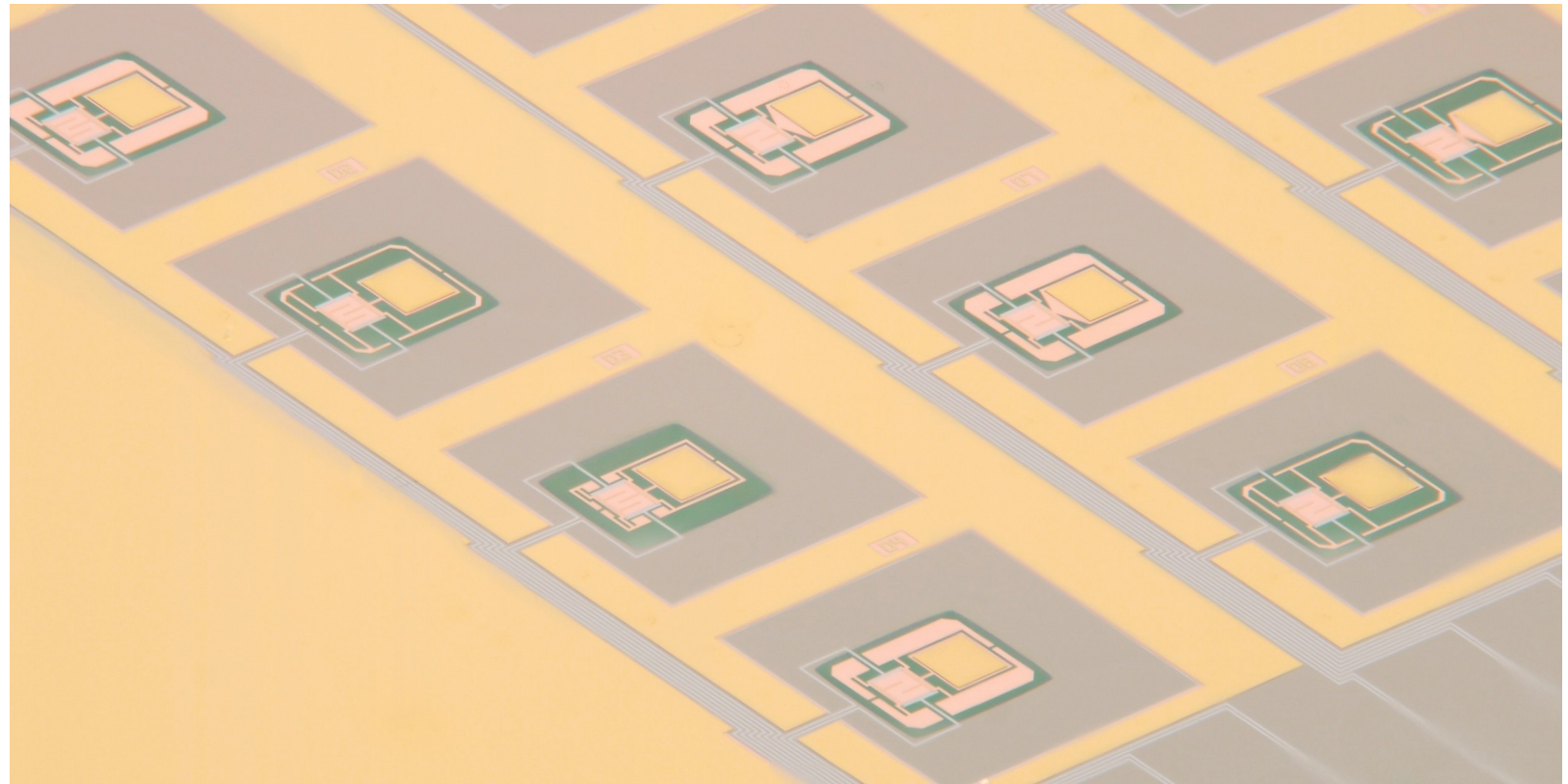
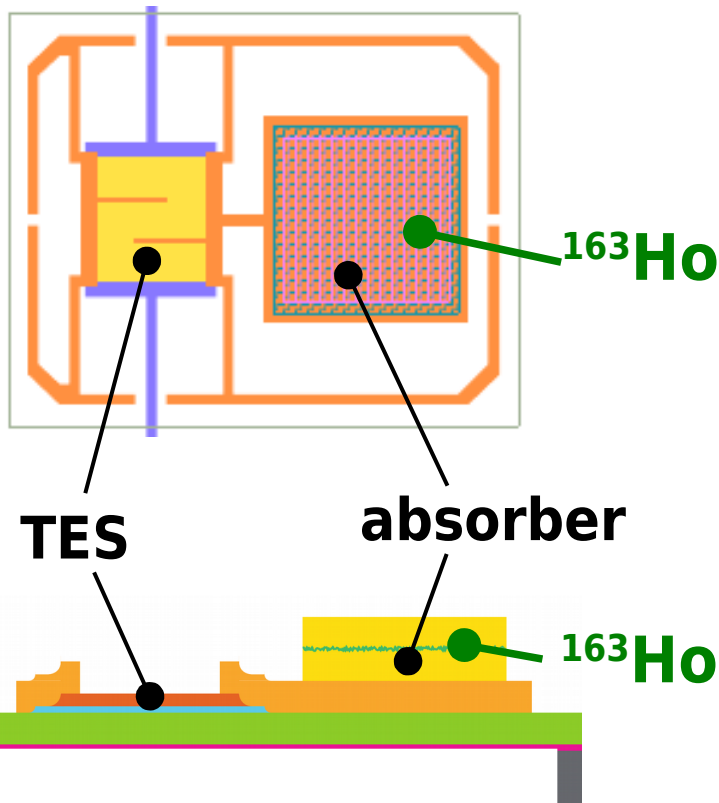


**99.99998%
full stopping
for 2keV electrons**

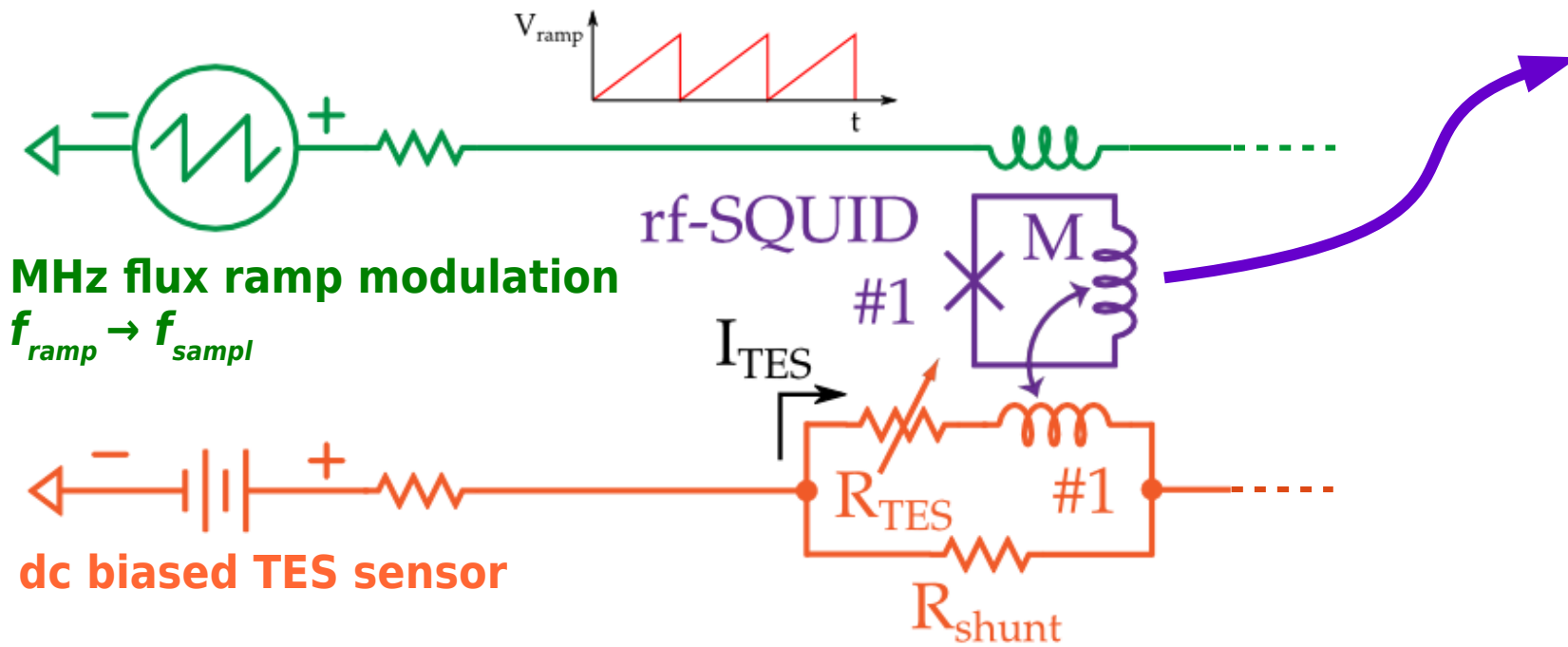
HOLMES pixel design and test



- optimize design for speed and resolution
 - ▷ **specs @3keV** : $\Delta E_{FWHM} \approx 1\text{eV}$, $\tau_{\text{rise}} \approx 10\mu\text{s}$, $\tau_{\text{decay}} \approx 100\mu\text{s}$
- **2 μm Au** thickness for *full* electron and photon absorption
- **side-car** design to avoid TES proximitation and G engineering for τ_{decay} control
- **NIST** designed and fabricated 4x6 arrays of **TES prototypes** for optimization **w/o ^{163}Ho**



HOLMES array read-out: rf-SQUID



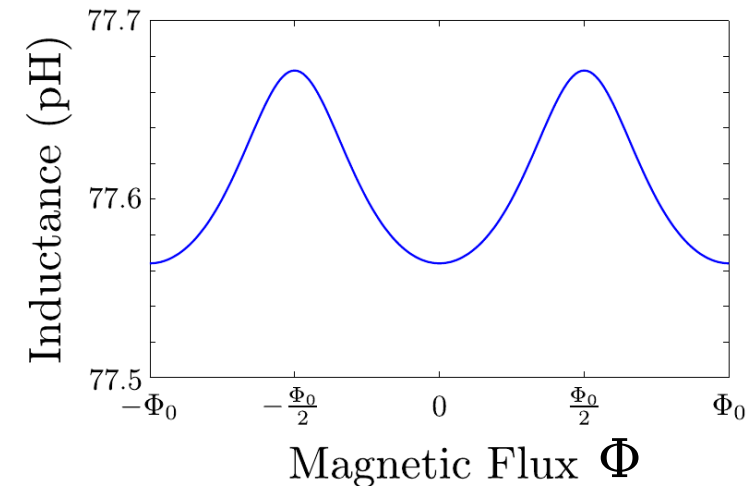
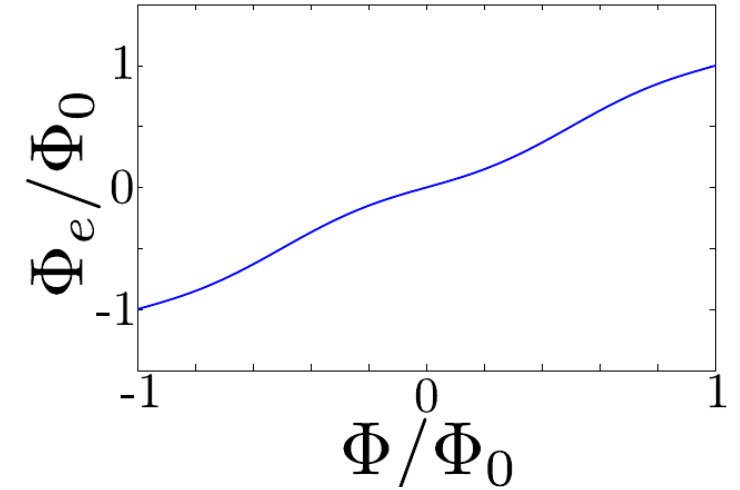
MHz flux ramp modulation

$$f_{ramp} \rightarrow f_{sAMPL}$$

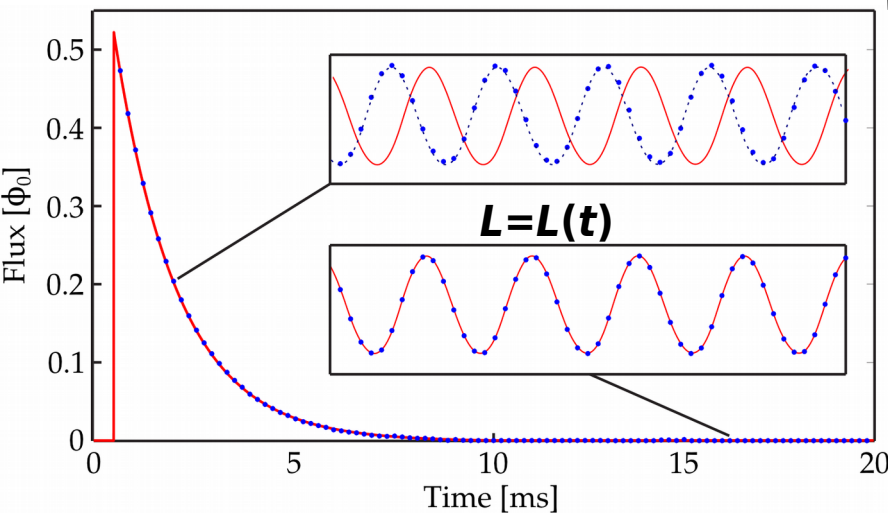
dc biased TES sensor

non-hysteretic rf-SQUID

Φ_e vs. Φ and L vs. Φ responses

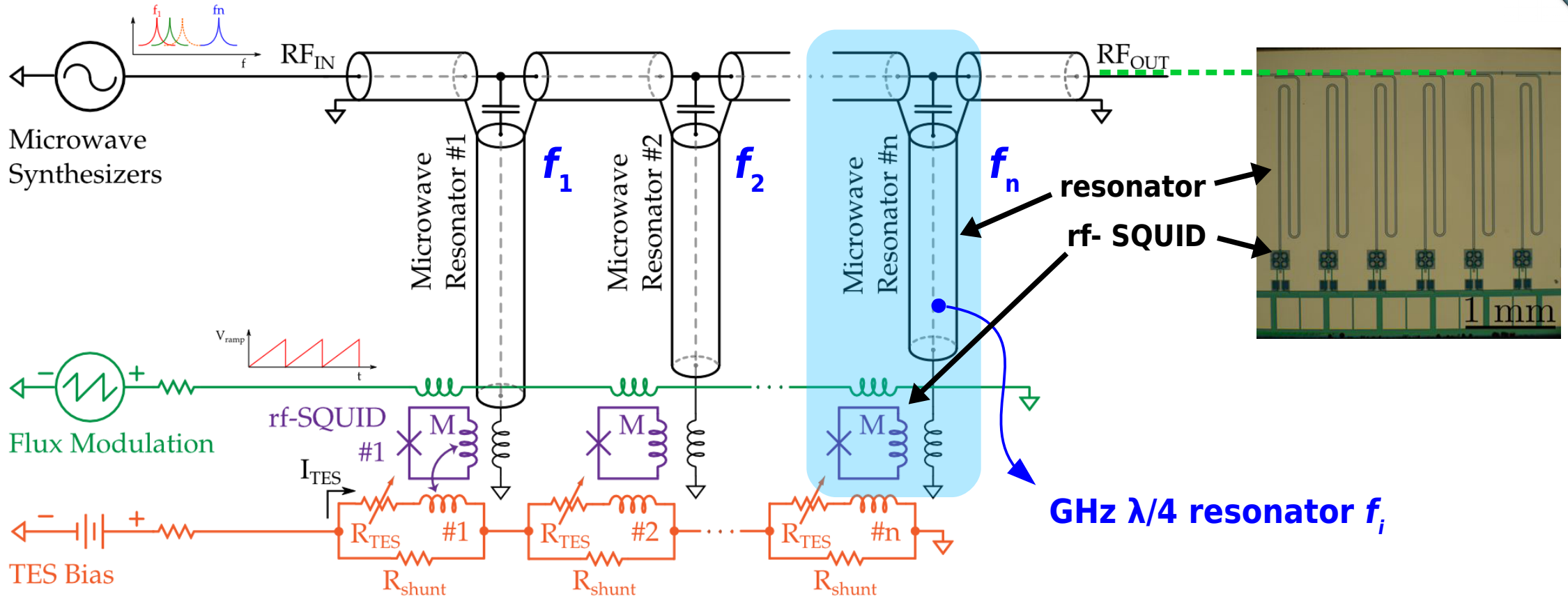


$$\Delta T \rightarrow \Delta R_{TES} \rightarrow \Delta I_{TES} \rightarrow \Delta \Phi_e \rightarrow \Delta \Phi \rightarrow \Delta L$$

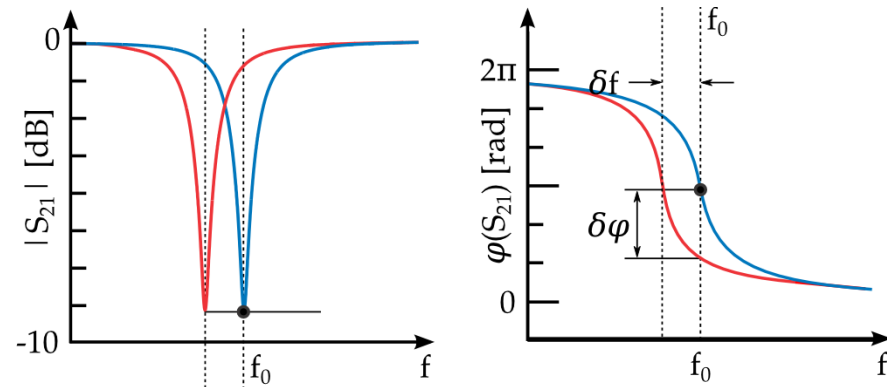
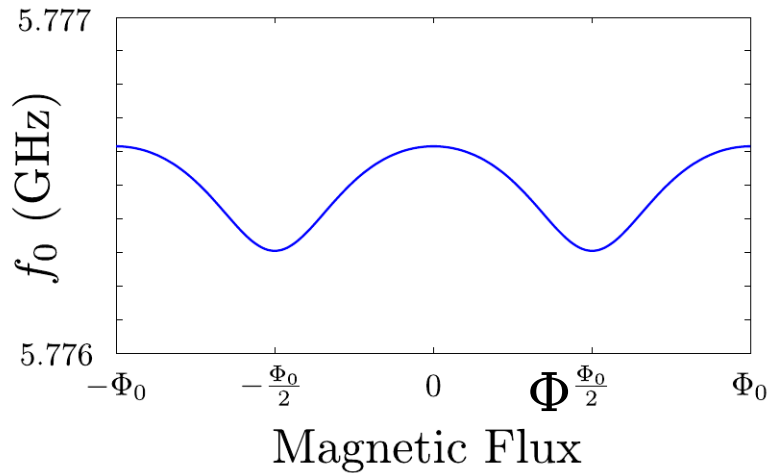


- $\Phi_e = \Phi_{TES} + \Phi_{ramp}$
- **flux-ramp modulation**
 - phase modulated MHz signal $L(t)$
 - linearized non-hysteretic rf-SQUID response
 - avoid low frequency noise sources

HOLMES array read-out: microwave multiplexing



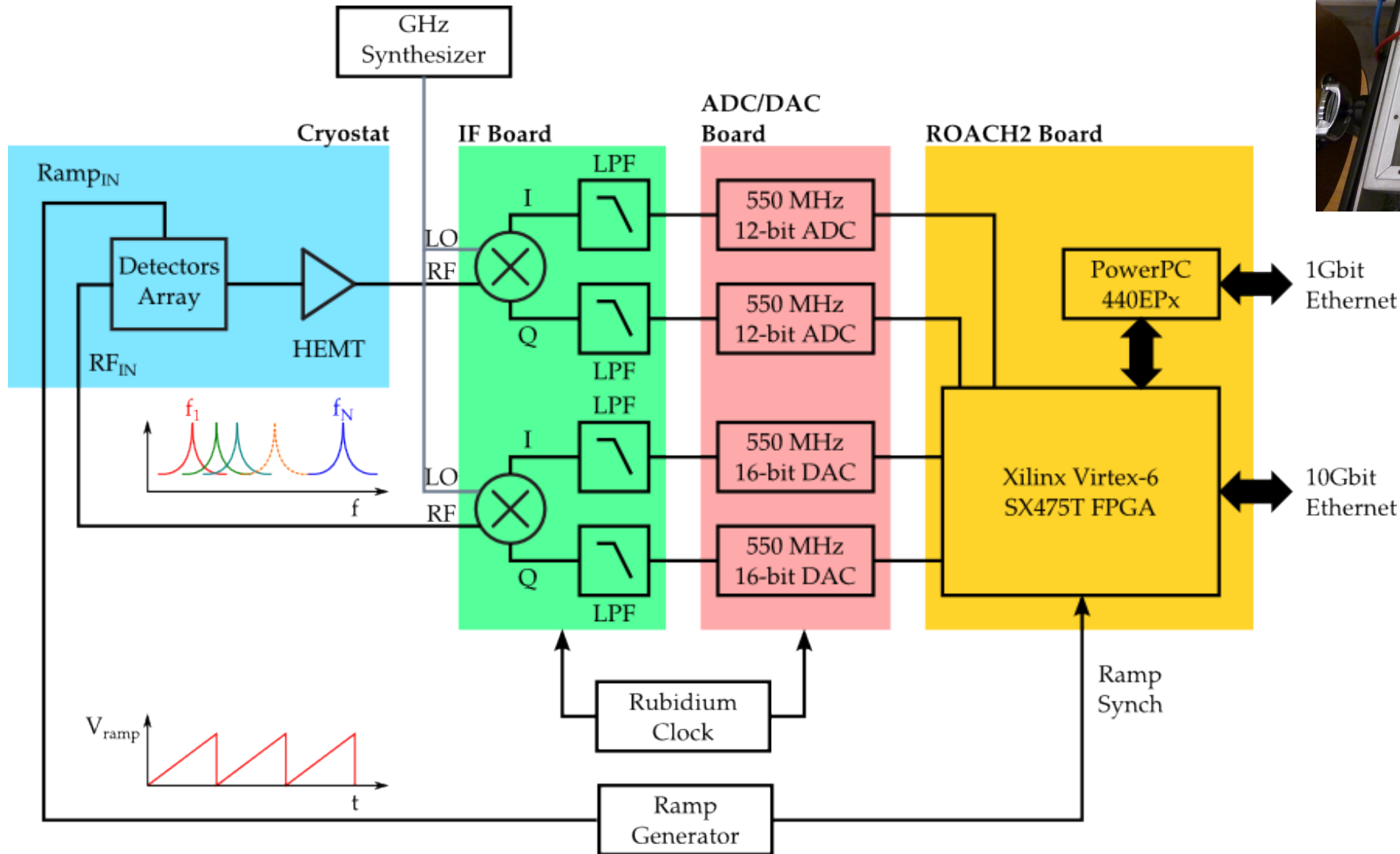
$$\dots \rightarrow \Delta\Phi \rightarrow \Delta L \rightarrow \Delta f_0 \rightarrow (\Delta A, \Delta\varphi) \rightarrow (\Delta I, \Delta Q)$$



HOLMES DAQ: Software Defined Radio



- base-band tone generation (0-512MHz)
- up- / down-conversion (base-band \rightarrow 4-8 GHz \rightarrow base-band)
- base-band tone IQ de-modulation (0-512MHz)
- rf-SQUID phase signal de-modulation by Fourier analysis

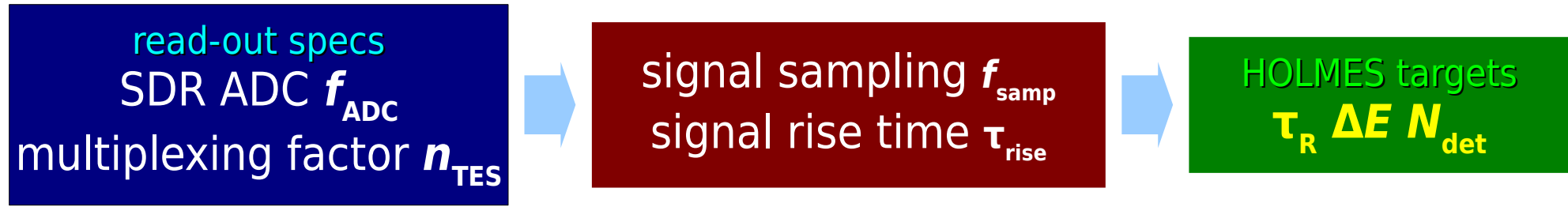


HOLMES detector design



design mostly driven by **read-out bandwidth** requirements

- ▶ TES microwave multiplexing with rf-SQUID ramp modulation + Software Defined Radio (SDR)



$$f_{\text{samp}} \geq \frac{R_d}{\tau_{\text{rise}}} \approx \frac{5}{\tau_{\text{rise}}} \quad \text{detector signal sampling (signal BW)}$$

$$f_{\text{res}} \geq 2 n_{\Phi_0} f_{\text{samp}} \quad \text{flux ramp modulated signal BW (resonator BW)}$$

$$f_n \geq g_f f_{\text{res}} = \frac{2 R_d g_f n_{\Phi_0}}{\tau_{\text{rise}}} \quad \text{microwave tones separation } (g_f \gtrsim 7)$$

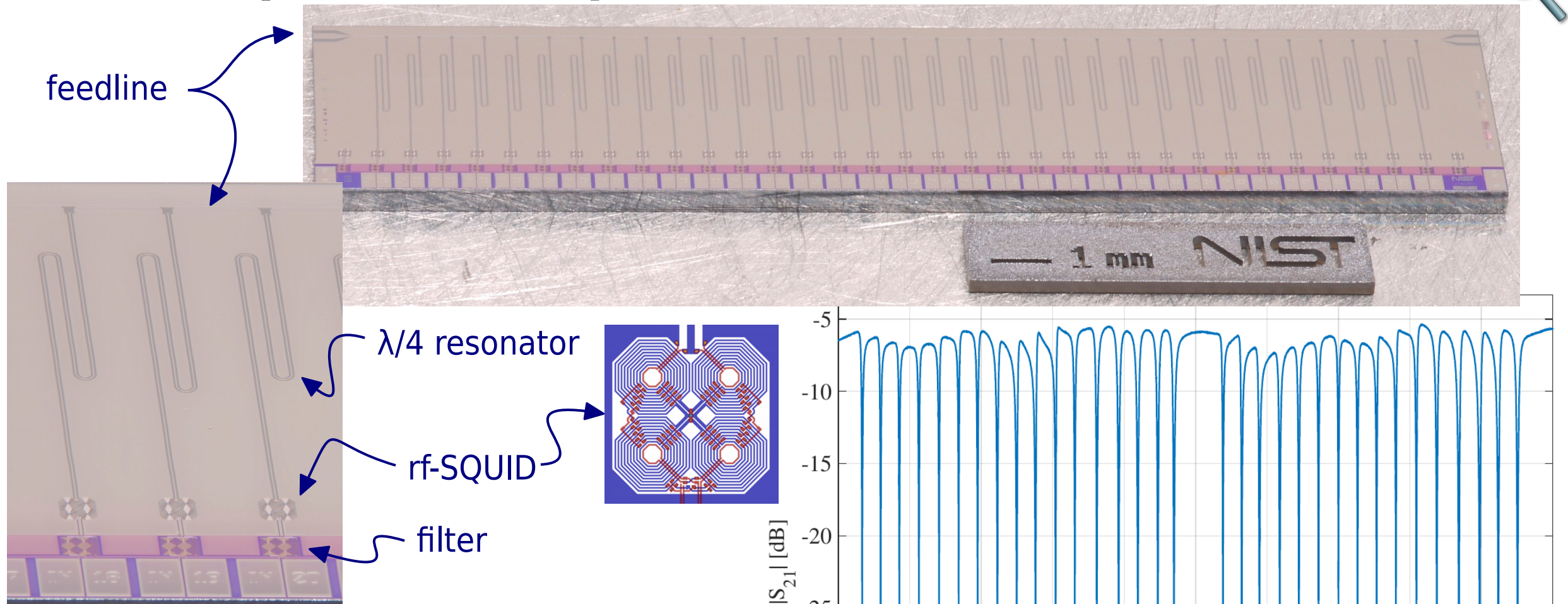
multiplexing factor →

$$n_{\text{TES}} = \frac{f_{\text{ADC}}}{f_n} \leq \frac{f_{\text{ADC}} \tau_{\text{rise}}}{2 R_d g_f n_{\Phi_0}} \approx \frac{f_{\text{ADC}} \tau_{\text{rise}}}{140}$$

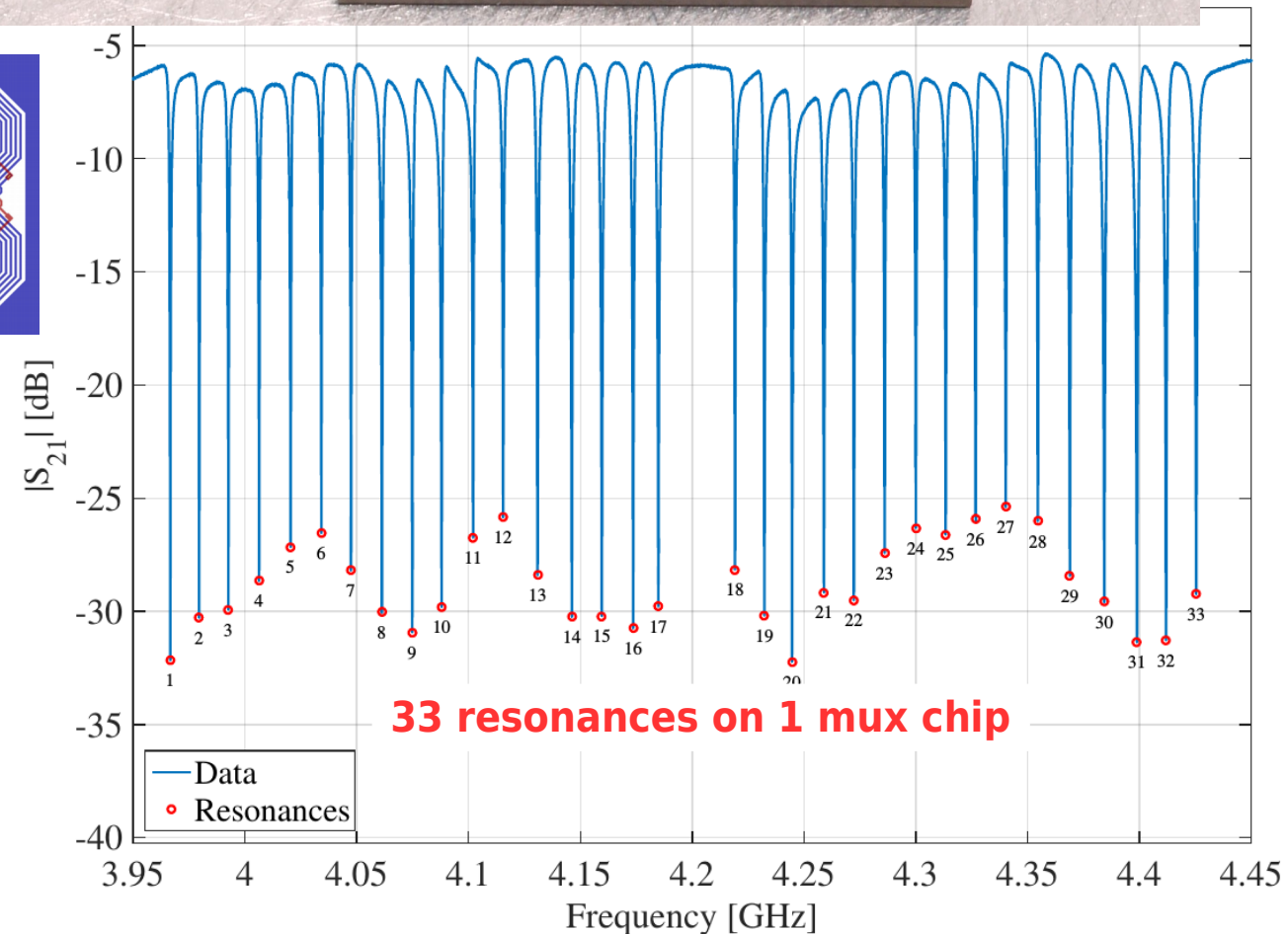
for fixed $f_{\text{ADC}} = 512 \text{MHz}$ and $n_{\text{TES}} = 32 \Leftrightarrow \tau_{\text{rise}} \approx 10 \mu\text{s}$ with $f_{\text{samp}} = 0.5 \text{MHz}$

→ check for slew rate, τ_R and $\Delta E \dots$

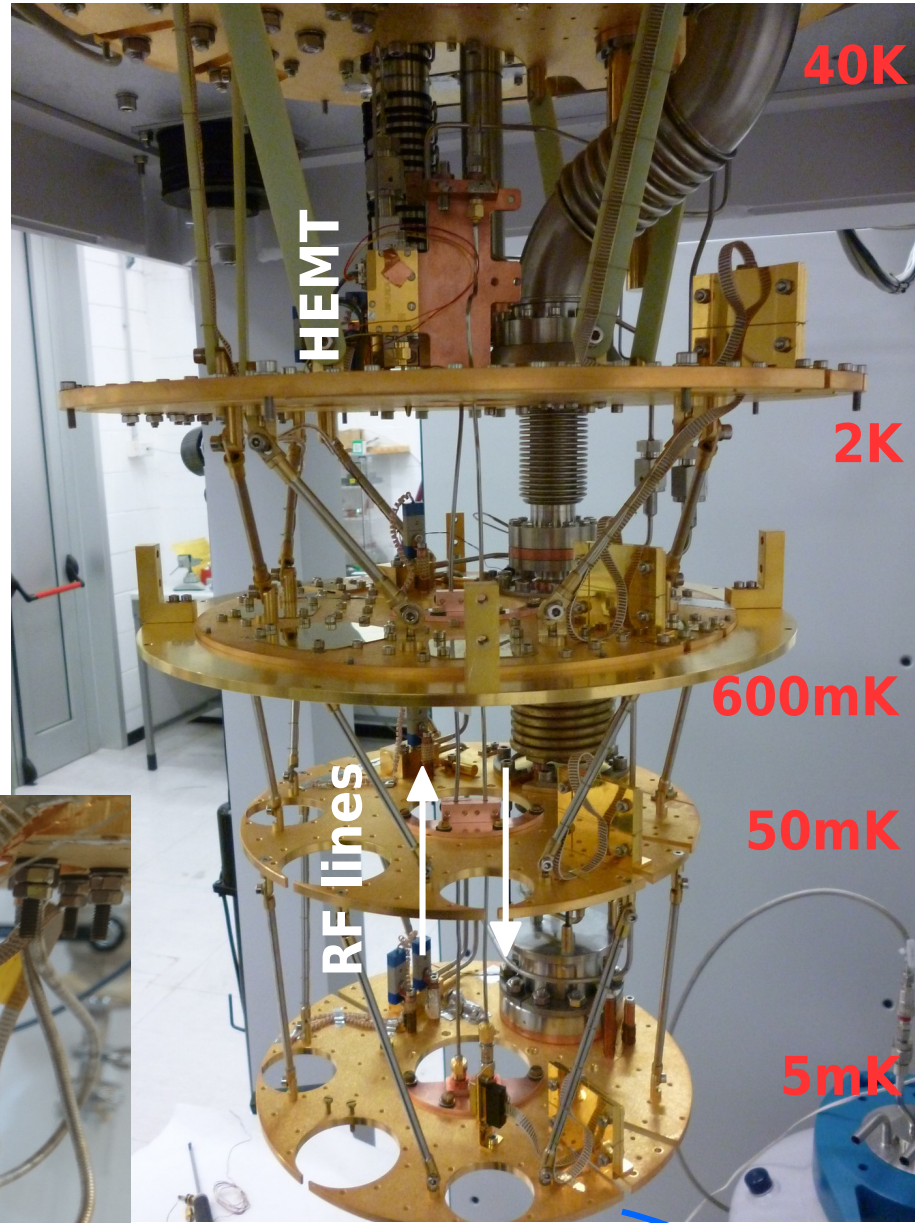
HOLMES μ wave multiplexed TES read-out



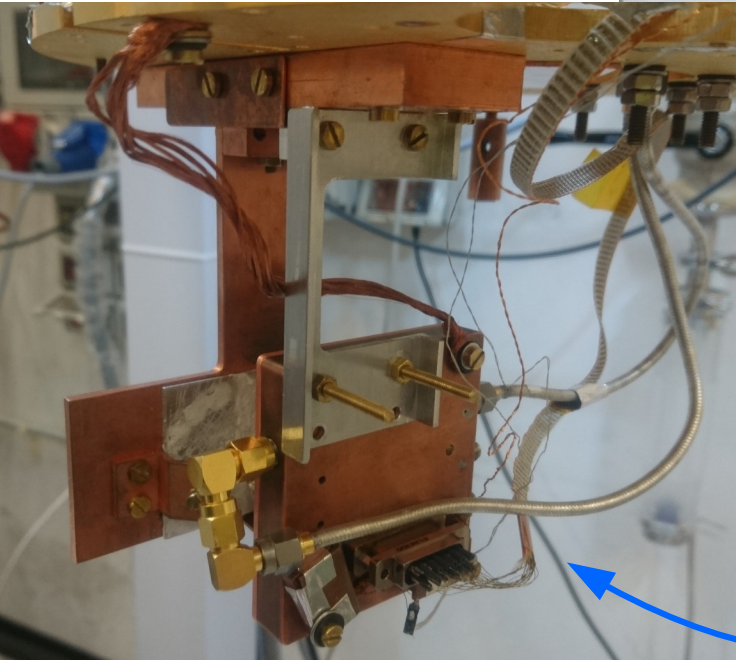
- **μ MUX17A** optimized for **HOLMES**
- 33 resonances in 500 MHz
 - ▶ width $f_{\text{res}} = 2$ MHz
 - ▶ separation 14 MHz ($g_f = 7$)
- squid noise $< \approx 2 \mu\Phi_0/\sqrt{\text{Hz}}$



Cryogenic set-up



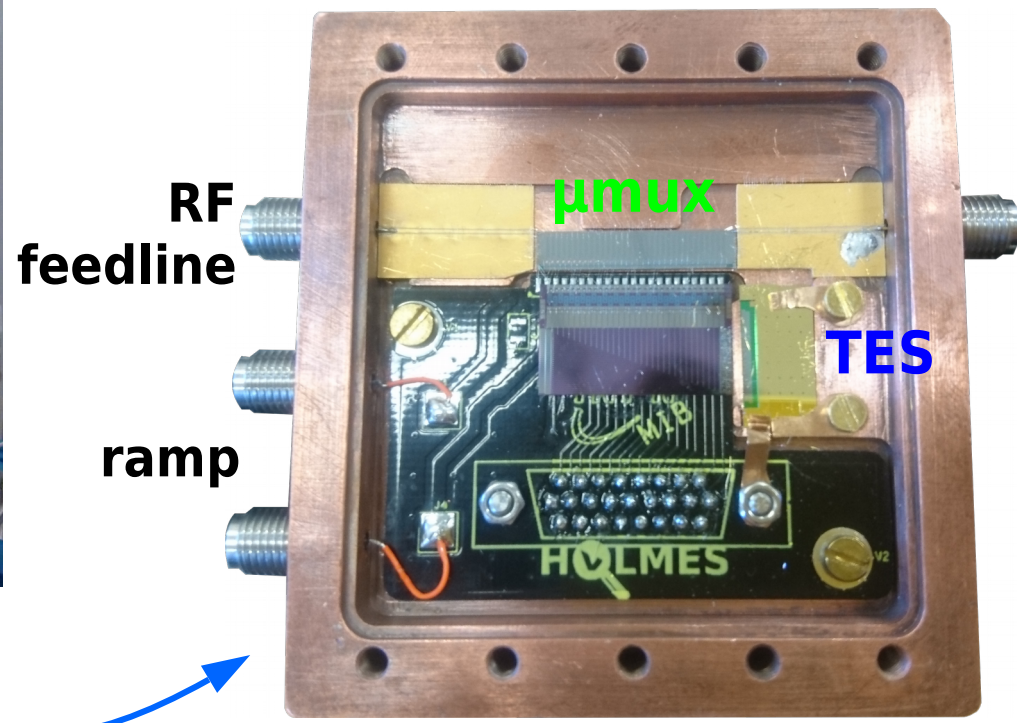
detector holder
mounted with
calibration source



LHe-free dilution fridge

- 1 HEMT + 2 coax RF lines
- 8 μ mux chips
- 256 detectors

detector holder

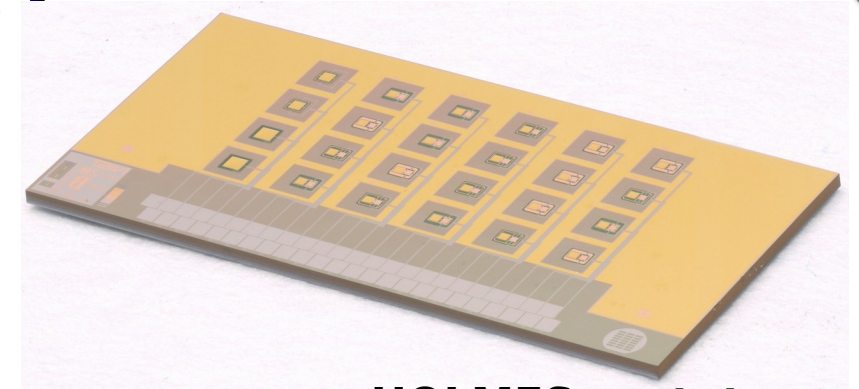


TES pixel testing with HOLMES DAQ / 1

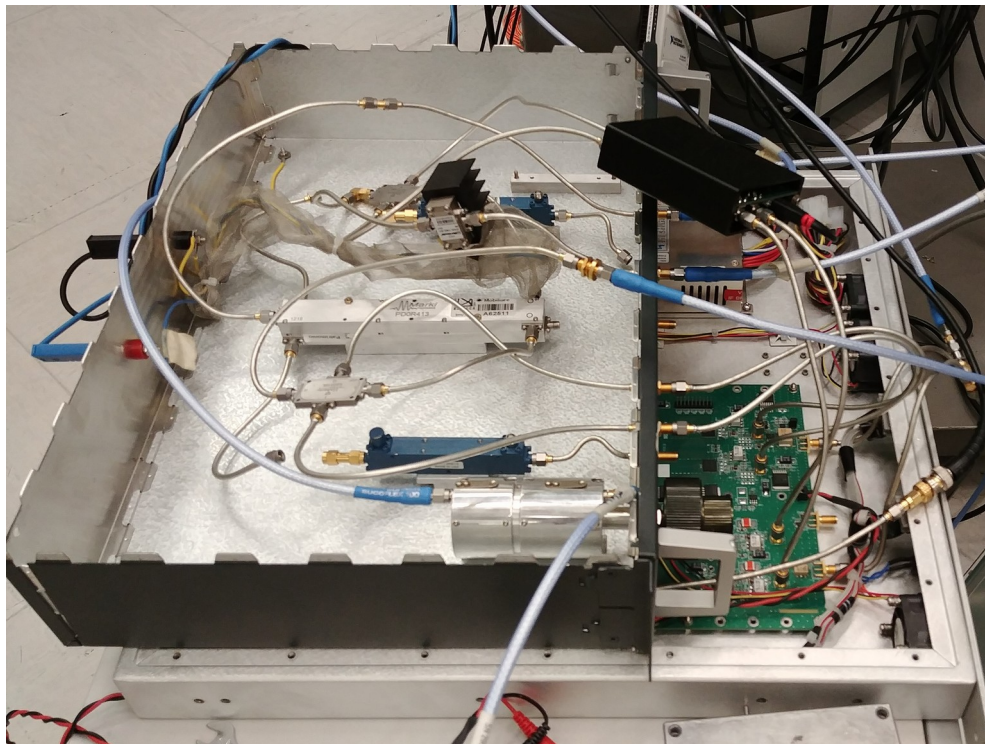


ROACH-2 based Software Defined Radio

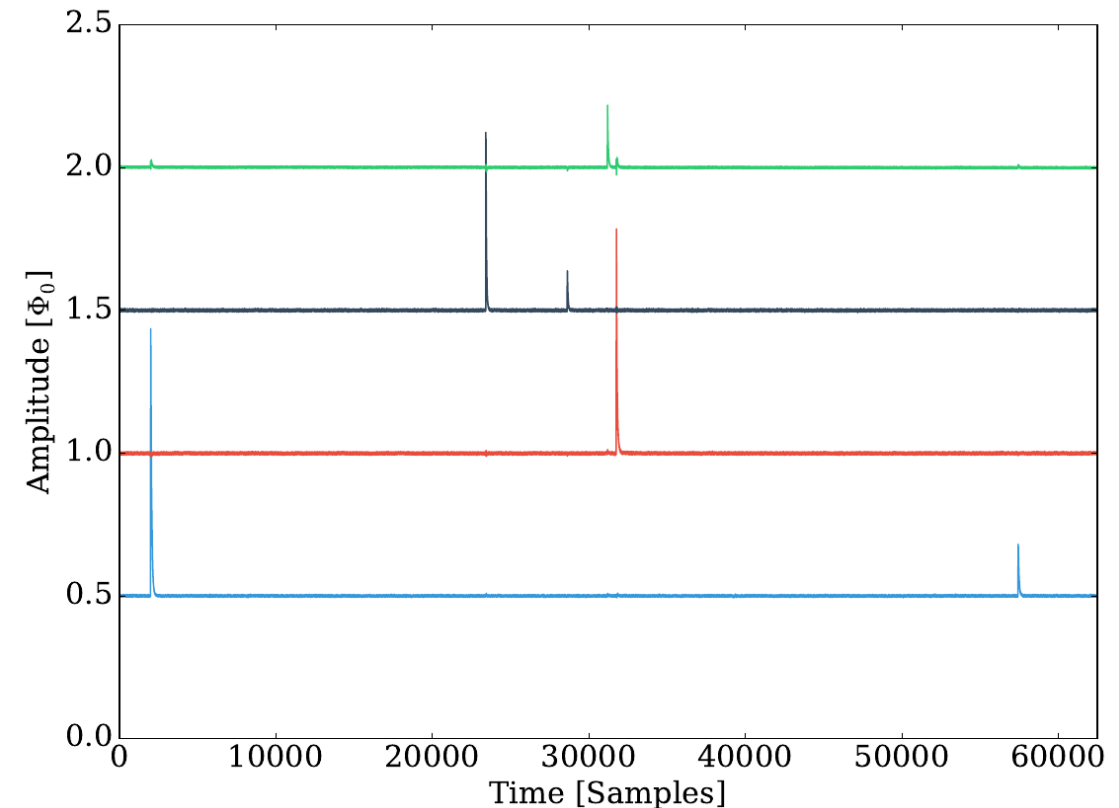
- ADC (550 MS/s 12bit) / DAC (1 GS/s 16bit)
- discrete components IF circuitry (up- / down- conversion)
- $n_{\phi_0} = 2$, $f_{\text{samp}} = 500$ kS/s
- 16 ch firmware from NIST (uses only half of available ADC bandwidth)
- 4 HOLMES prototypes acquired \leftrightarrow limited by available tone power
- **goals:** check algorithms, noise, ΔE , τ_R and slew rate



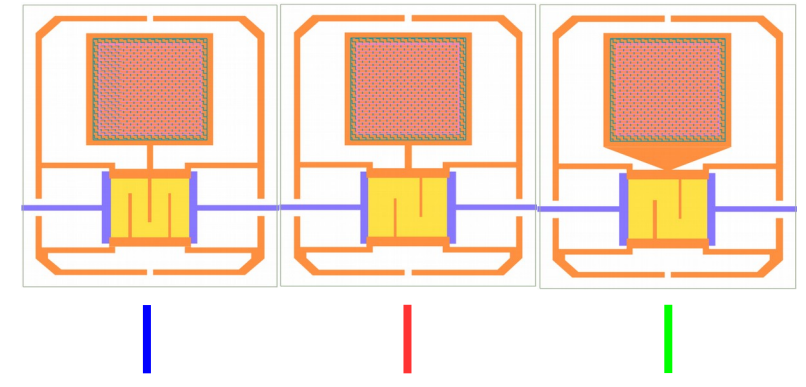
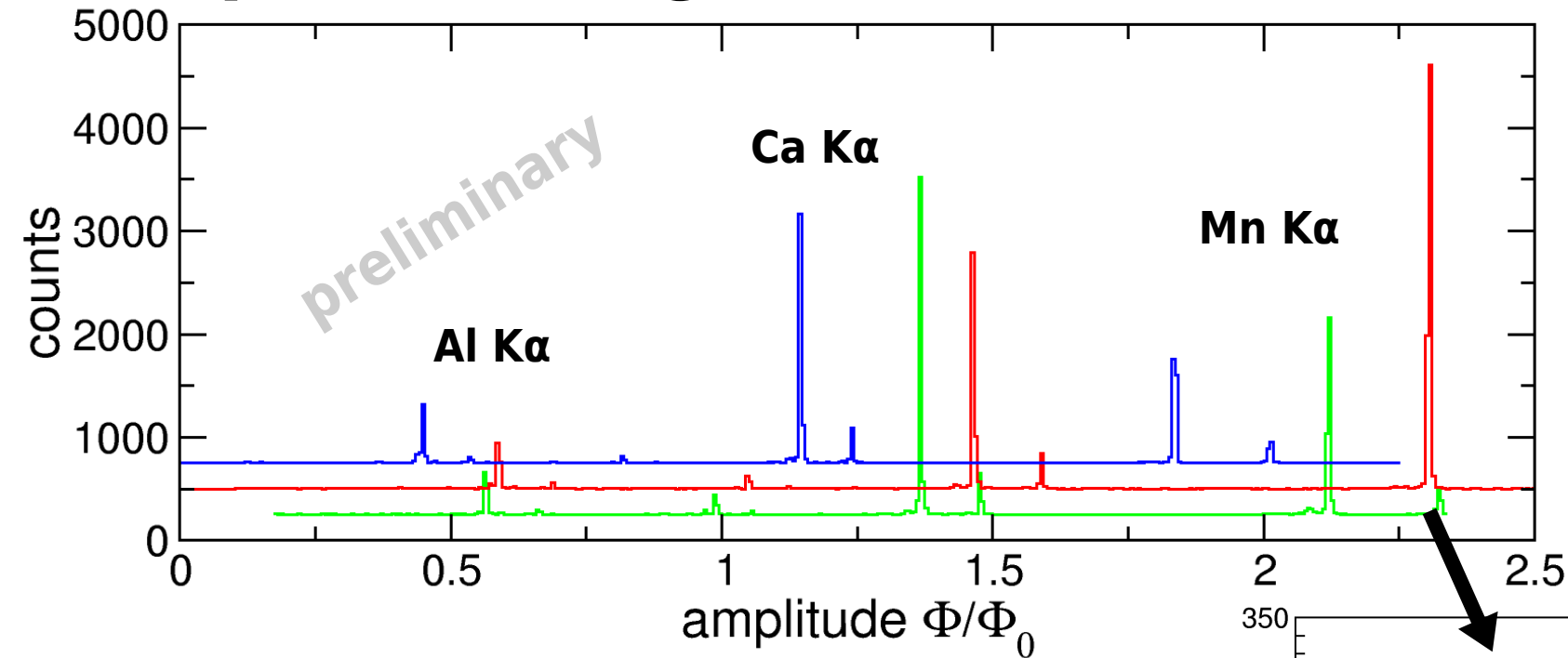
HOLMES prototypes



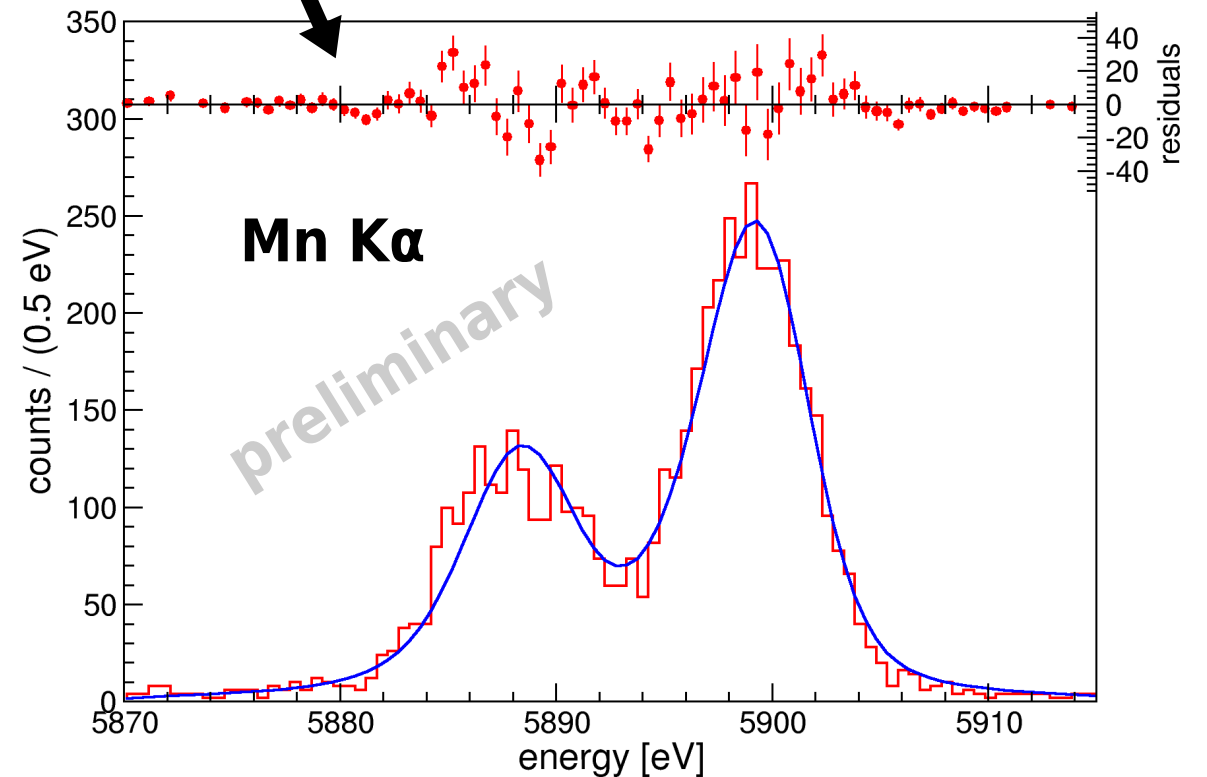
ROACH + IF circuit



TES pixel testing with HOLMES DAQ / 2



- $\Delta E_0 \approx 3.3$ eV
- $\Delta E_{FWHM} = 4.5 \pm 0.1$ eV @ 6 keV
- $\tau_{rise} \approx 13$ μ s
- $\tau_{decay} \approx 54$ μ s



Rise time pile-up

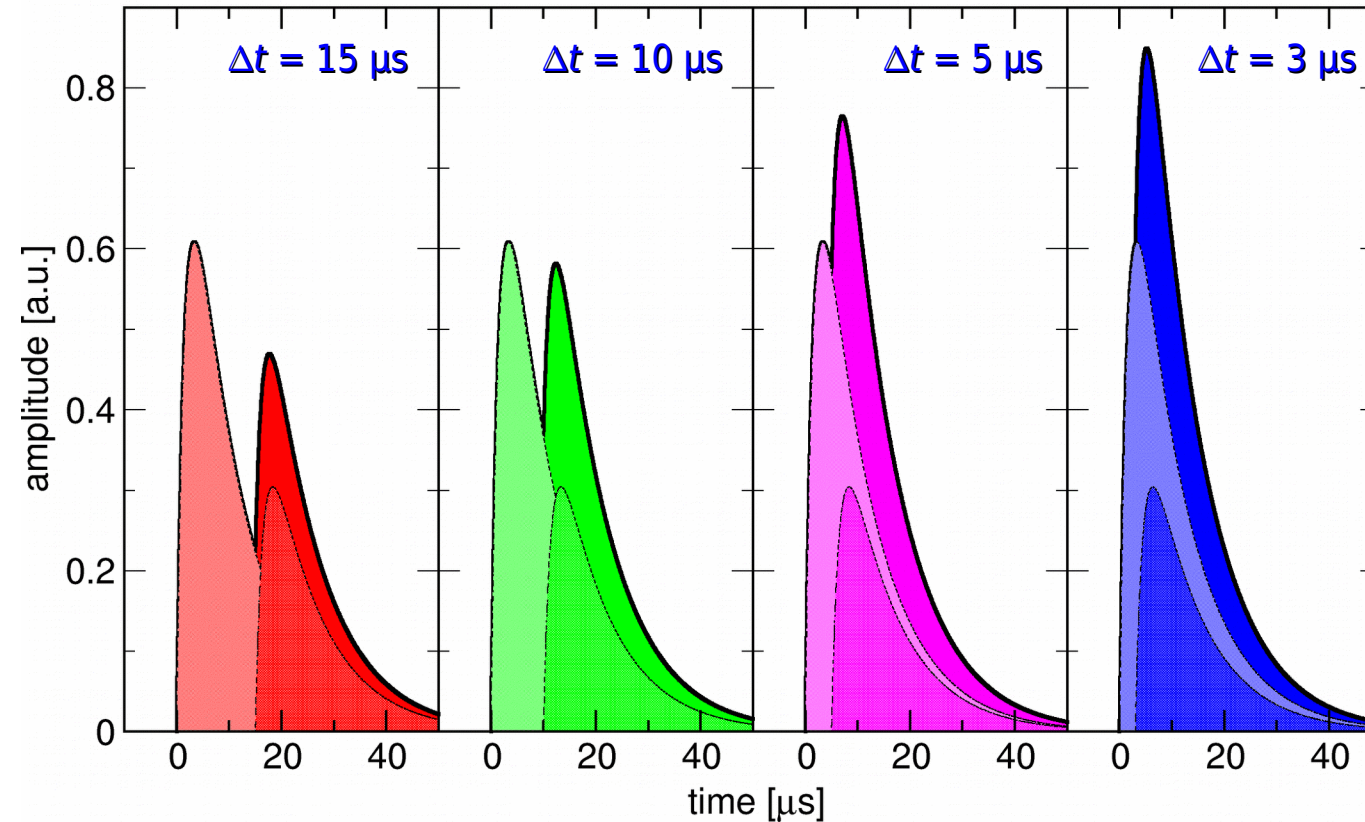


simple pulse model

$$A(t) = A(e^{-t/\tau_{decay}} - e^{-t/\tau_{rise}})$$

2 pulses with:

- $\tau_{rise} = 1.5 \mu\text{s}$
- $\tau_{decay} = 10 \mu\text{s}$
- $A_2/A_1 = 0.5$



resolving time $\tau_R \approx$ pulse rise time τ_{rise}

Detector time resolution



- for subsequent (Δt) events with energy E_1 and E_2 : time resolution $\tau_R = \tau_R(E_1, E_2)$

$$N_{pp}(E) = A_{EC} \int_0^{\infty} \tau_R(E, \epsilon) N_{EC}(\epsilon) N_{EC}(E - \epsilon) d\epsilon$$

- **Montecarlo pile-up spectrum simulations**

- ▷ event pairs with $E_1 + E_2 \in [2.4 \text{ keV}, 2.9 \text{ keV}]$ (drawn from ^{163}Ho spectrum), $\Delta t \in [0, 10\mu\text{s}]$

- ▷ pulse shape and noise from NIST TES model, sampled with f_{samp} , record length, and n bit

- **process with pile-up detection algorithms:**

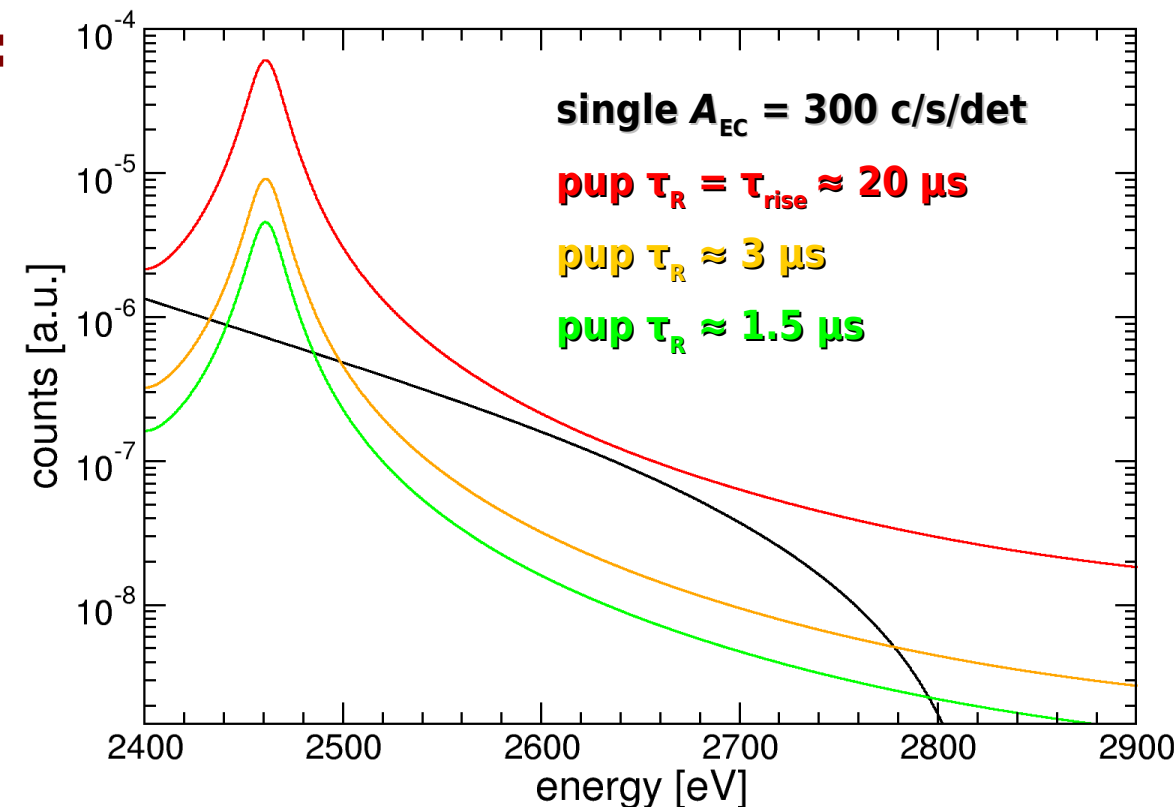
- ▷ for $f_{\text{samp}} = 0.5\text{MHz}$, $\tau_{\text{rise}} \approx 20\mu\text{s}$

- **Wiener Filtering**

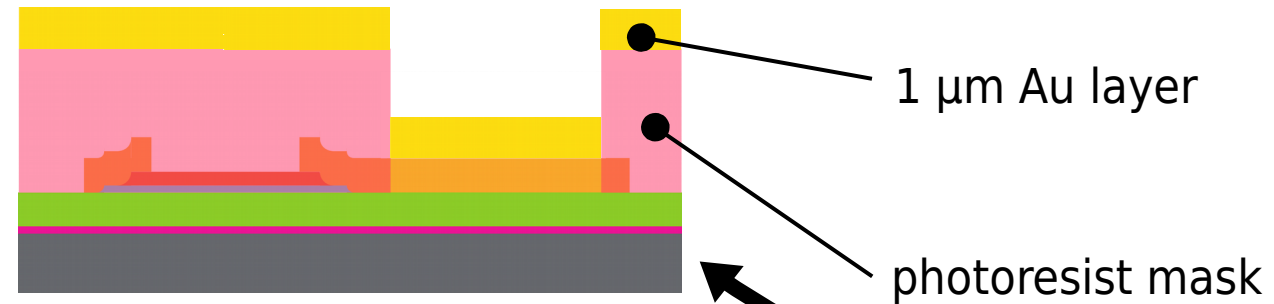
- $\tau_R \approx 3\mu\text{s}$

- **Singular Value Decomposition**

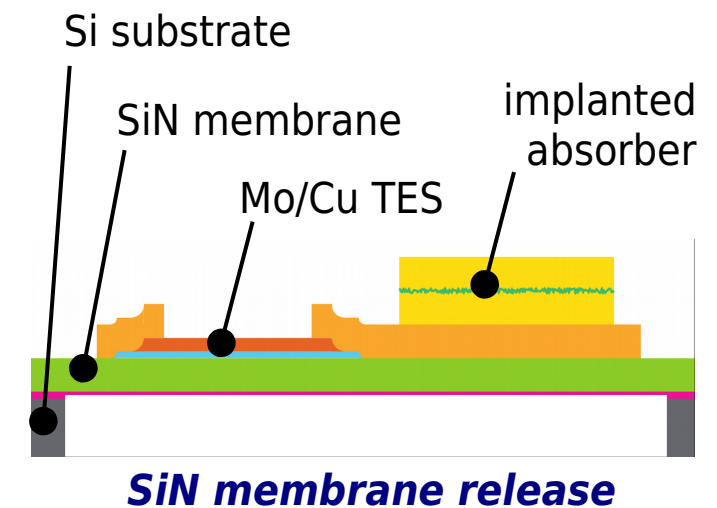
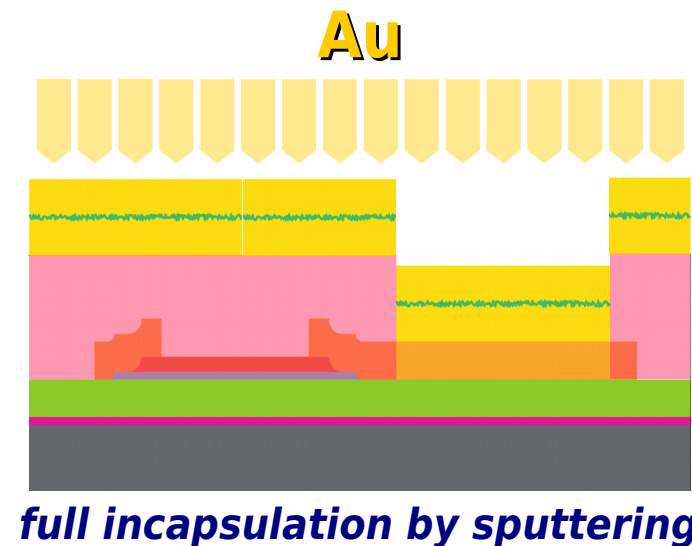
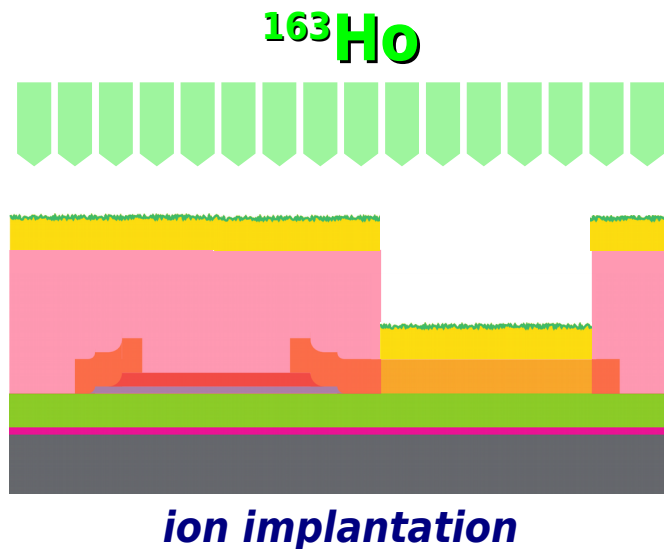
- $\tau_R \approx 1.5\mu\text{s}$



HOLMES array design and fabrication



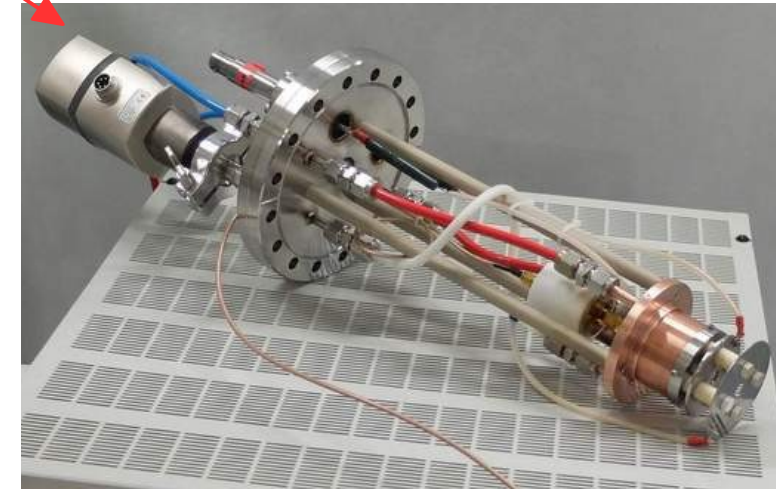
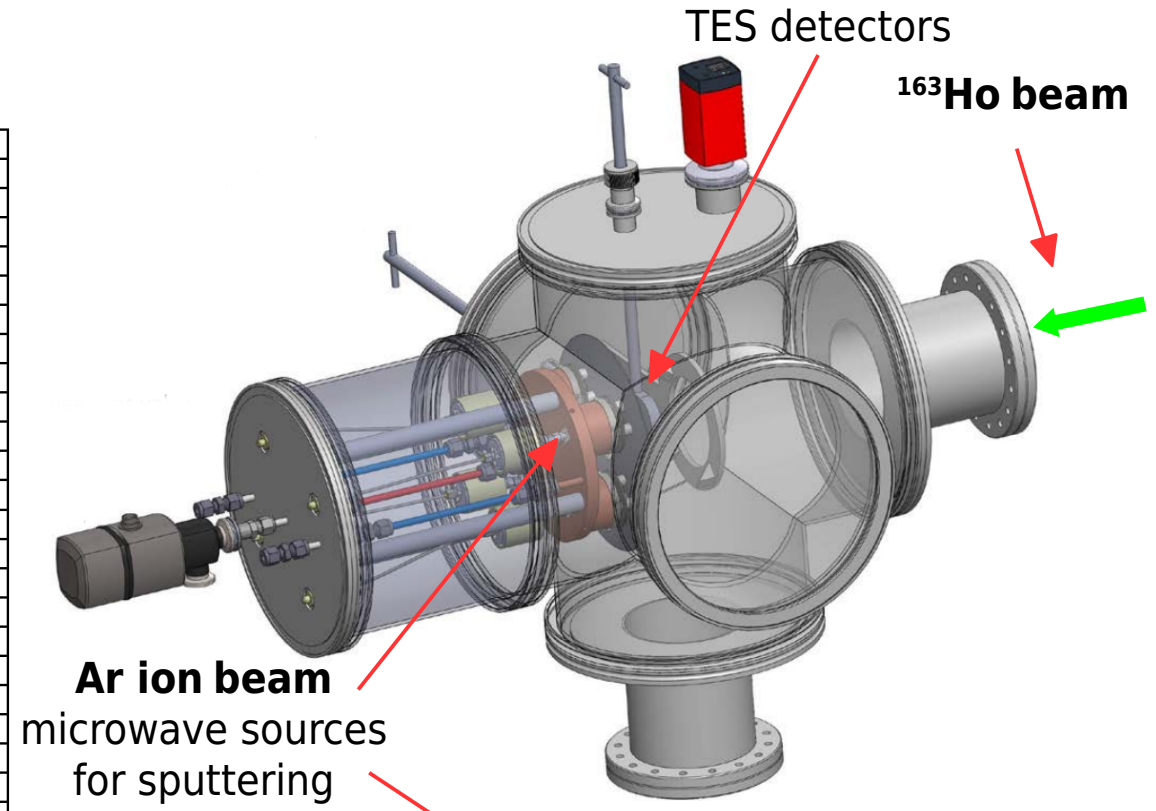
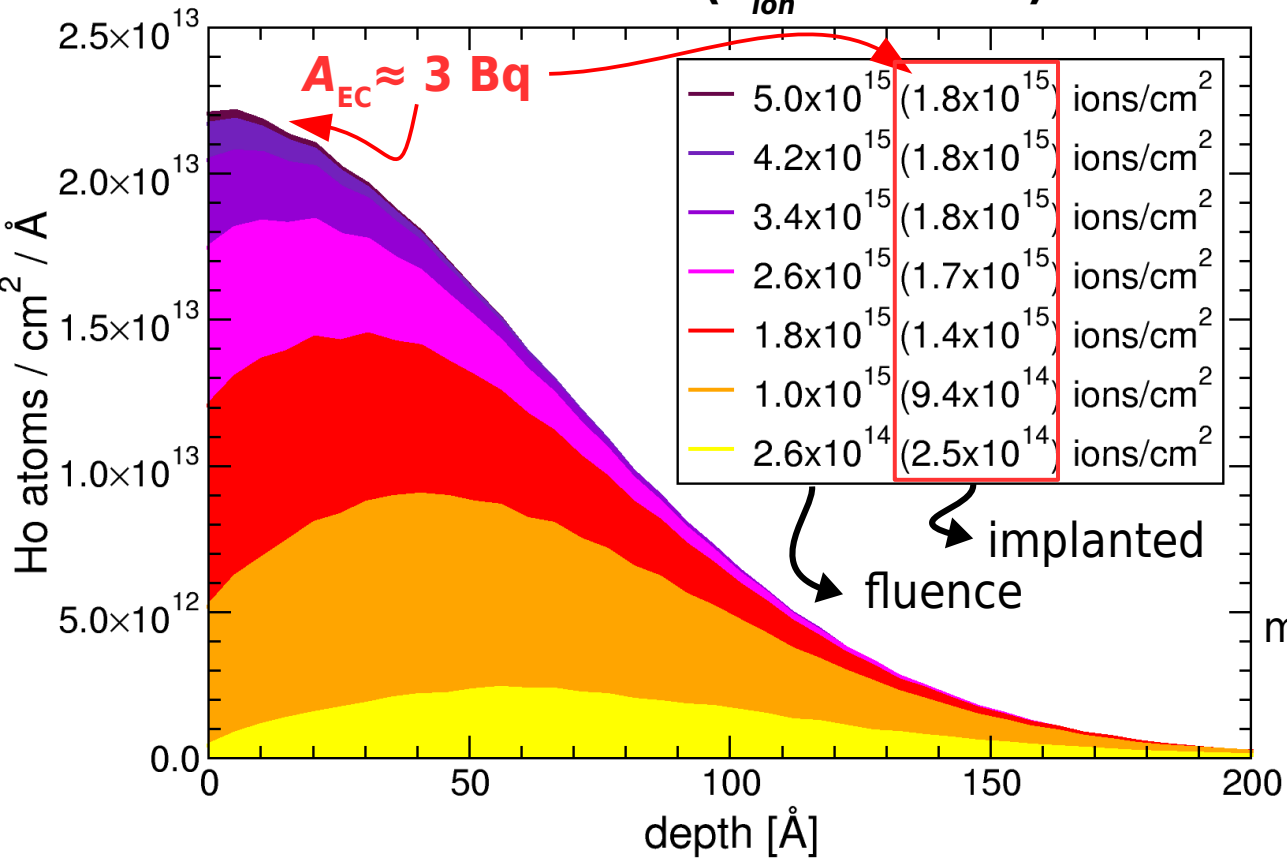
- TES array fabrication after first steps at **NIST**
- ^{163}Ho implantation and final 1 μm **Au** layer deposition
- final micromachining step definition in progress
- **4×16 sub-array** for low parasitic L and high implant efficiency



Target chamber for absorber fabrication / 1

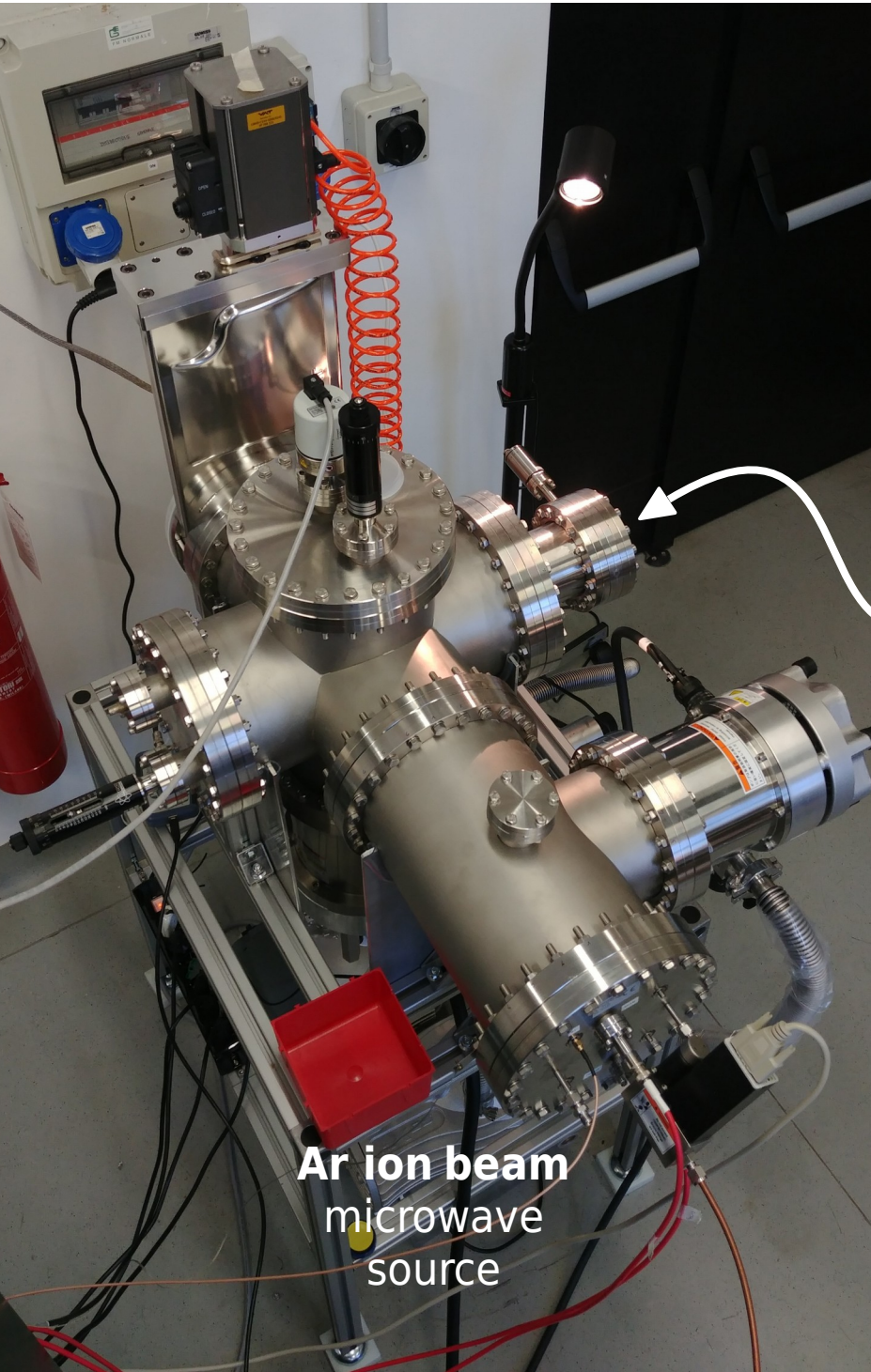


ion implant simulation with SRIM2013
 ^{163}Ho ions on Au ($E_{\text{ion}} = 50 \text{ keV}$)



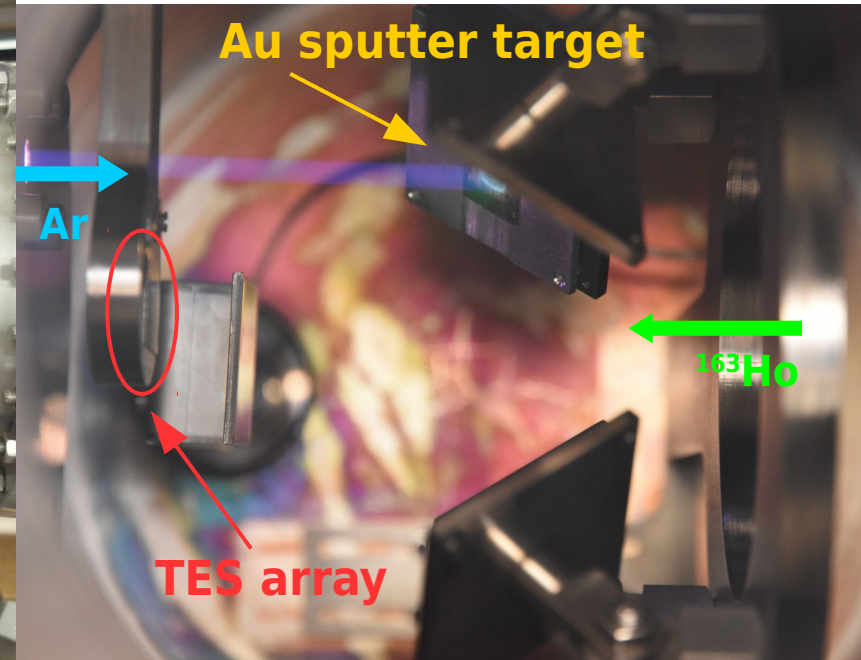
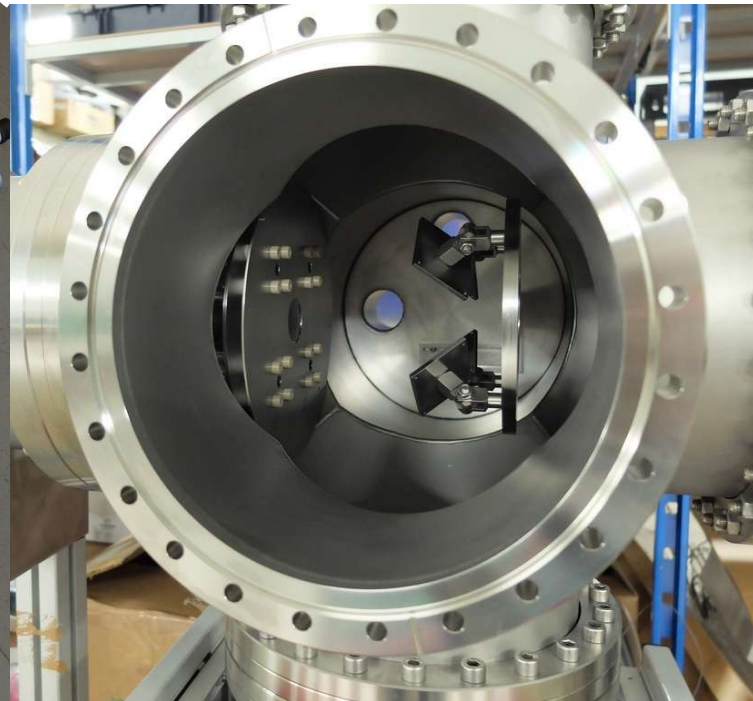
- ^{163}Ho ion beam sputters off Au from absorber ($\approx 26 \text{ Au/Ho}$)
 - ▶ implanted ^{163}Ho concentration in absorber saturates
 - ▶ compensate by Au co-evaporation
- final $1 \mu\text{m}$ Au layer in situ deposition
 - ▶ to prevent Ho oxidization

Target chamber for absorber fabrication / 2



Ar ion beam
microwave
source

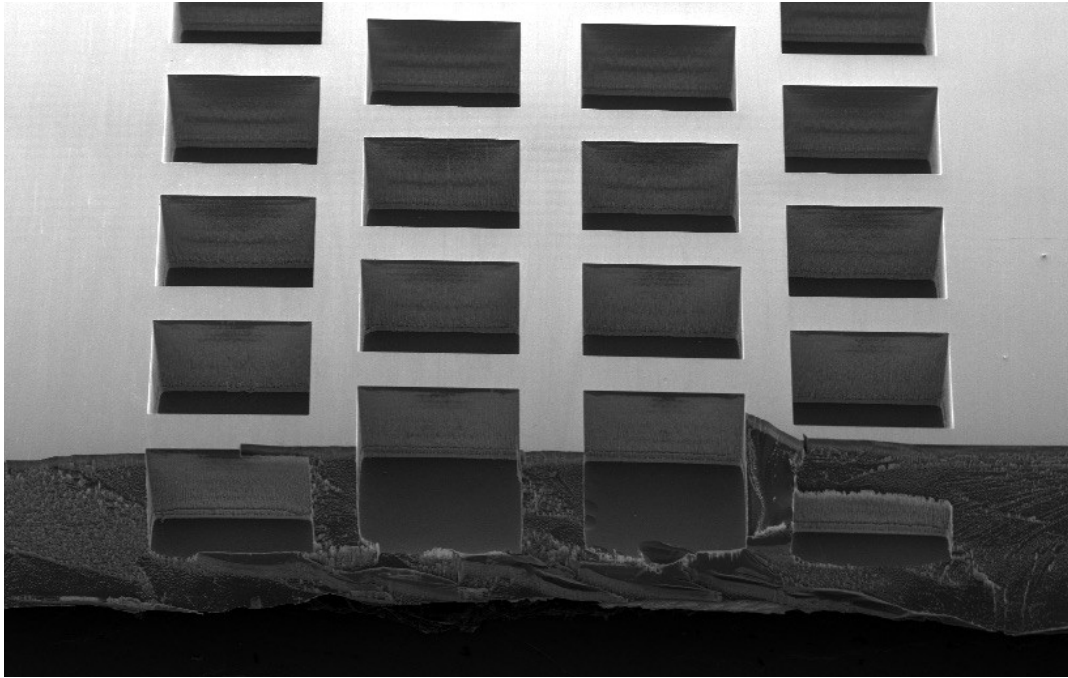
- Ion Beam Sputtering system for on-line deposition
- up to 4 ECR ion beam sources
- testing / optimization in progress with 1 ECR source
 - ▶ Au deposition rate control and maximization
 - ▶ Au film quality and uniformity characterization



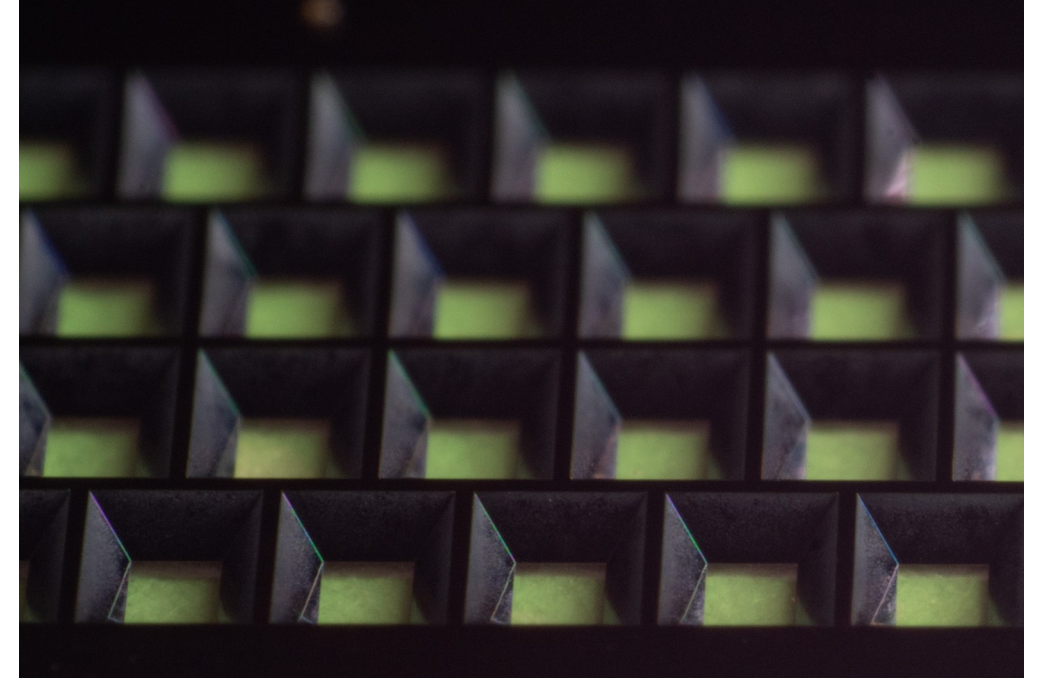
Detector array fabrication



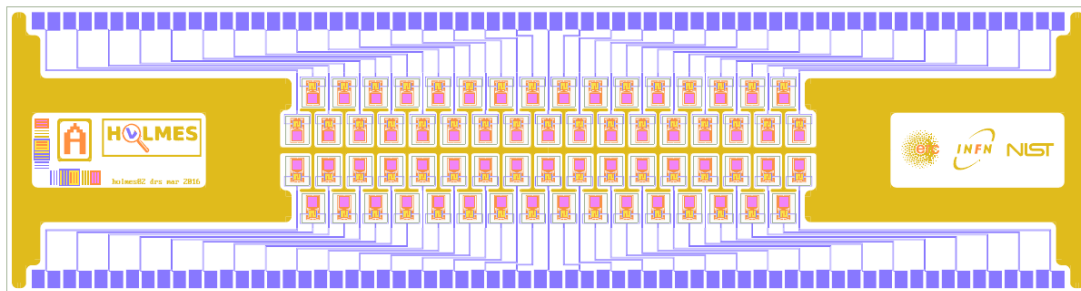
two options for membrane release (i.e. final array fabrication step)



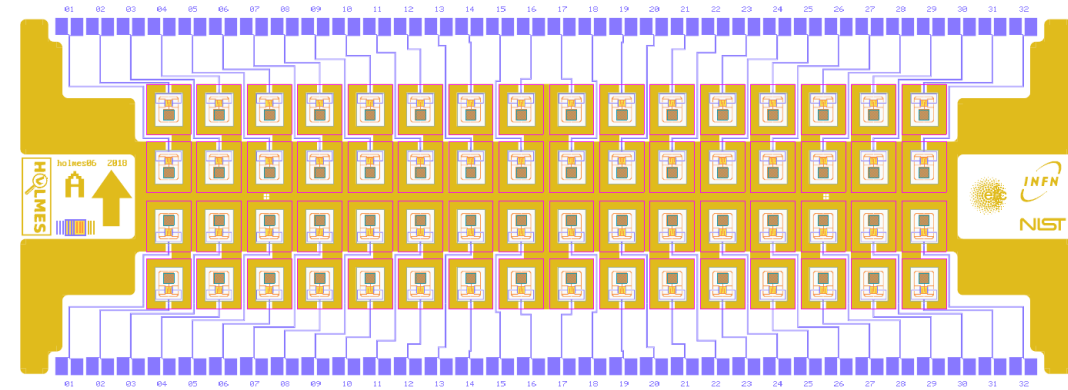
- Silicon Deep Reactive Ion Etching (DRIE)
- best for close packing and high implant efficiency
- not yet properly tuned → work in progress



- Silicon KOH anisotropic wet etching
- requires more spacing between pixels
- successfully tuned → **HOLMES baseline**



calculated ^{163}Ho
beam FWHM width



Conclusions

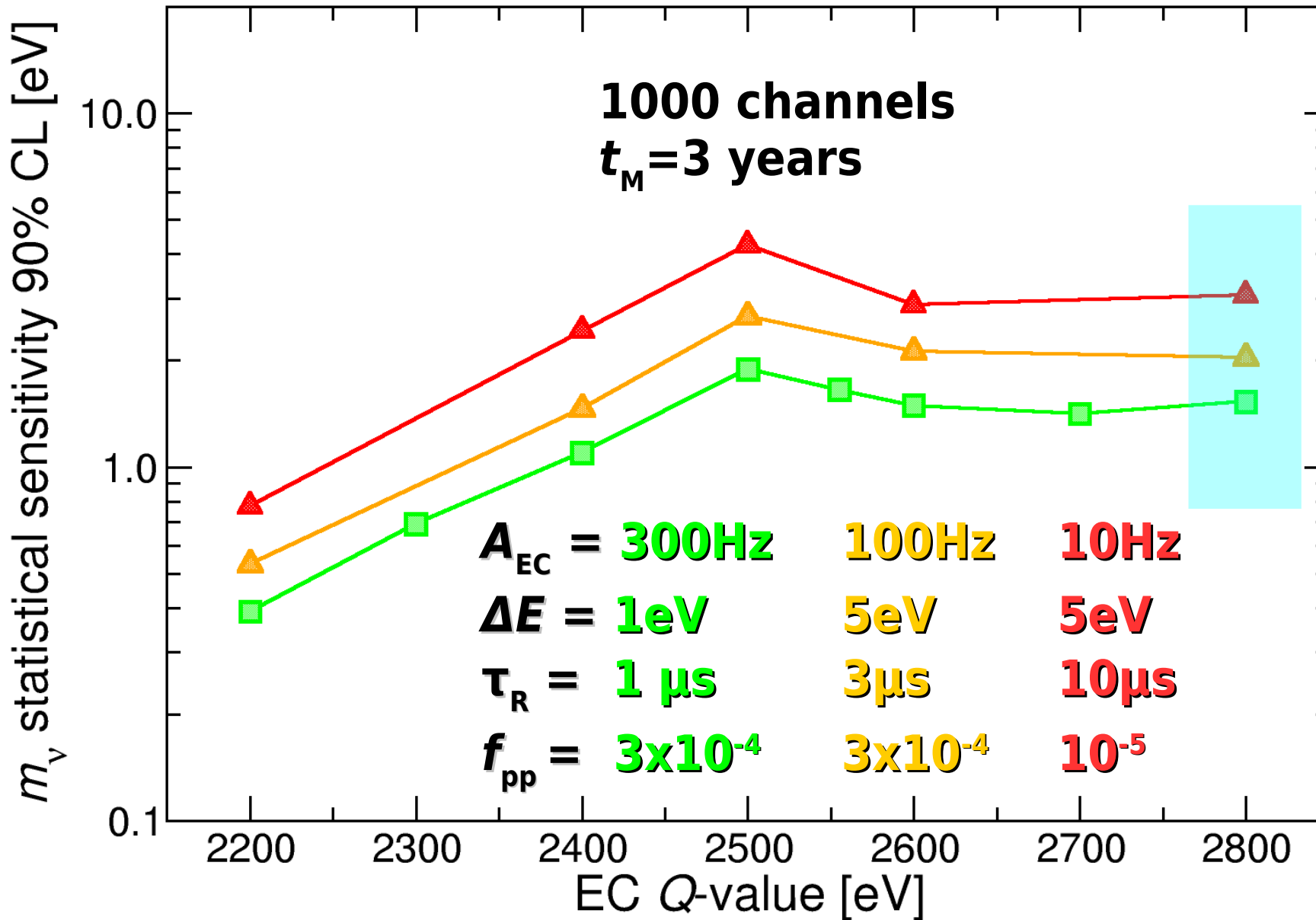


- first detector arrays are being fabricated at NIST
- first ion implantation tests with ^{163}Ho before the end of 2018
 - ▶ first not-optimized ion implanted detectors late in 2018
- ^{163}Ho implanted activity optimized during 2019
 - ▶ first high ^{163}Ho activity array running in 2019
 - ▶ 1 month data taking can provide a m_ν statistical sensitivity ≈ 10 eV
 - ▶ full array deployment will follow

Backup...



Worst case scenarios...



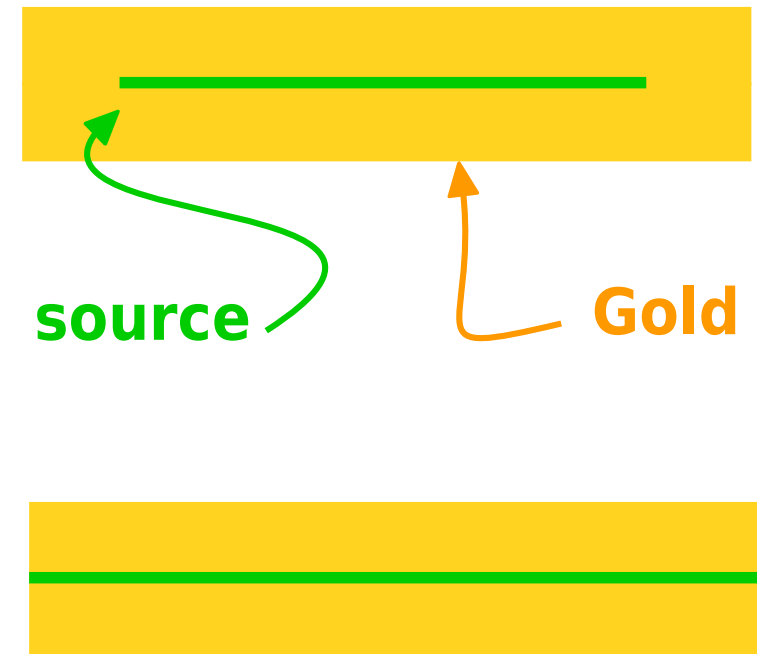
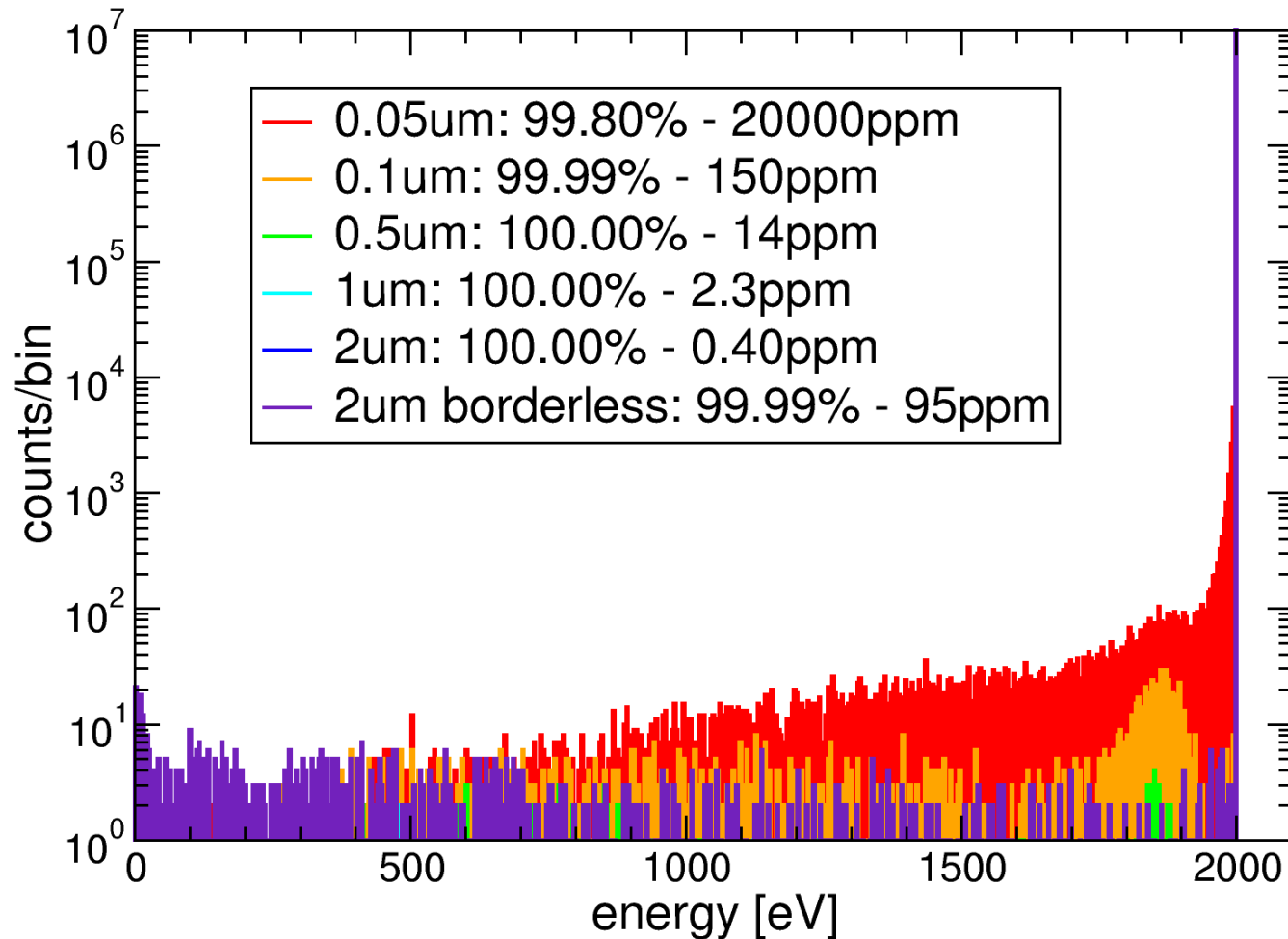
TES absorber design: stopping EC radiation / 1 b



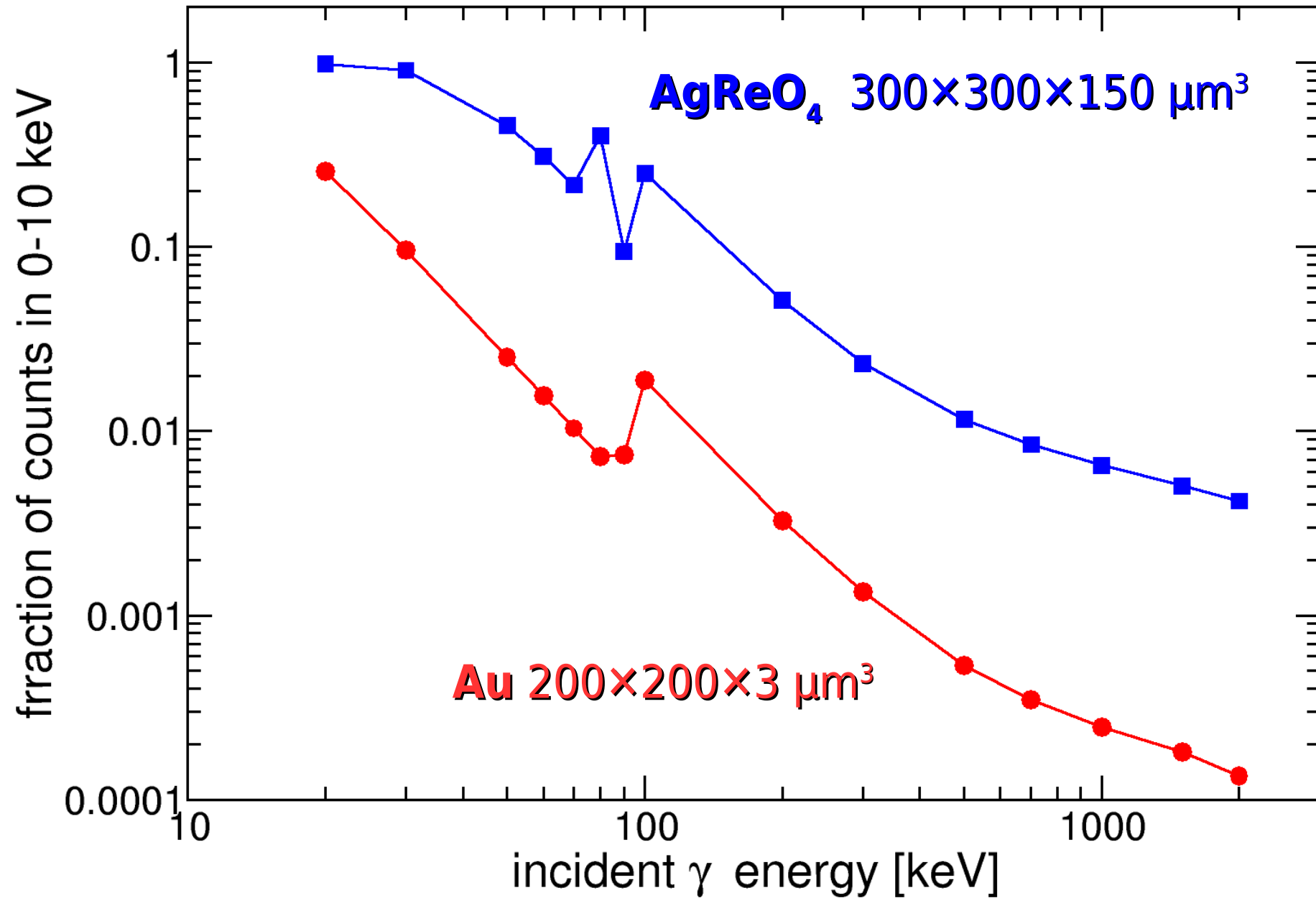
Geant4 + LowEnergyEM MC simulation

2keV electrons

full thickness: 0.05, 0.1, 0.5, 1, 2, 2 μm



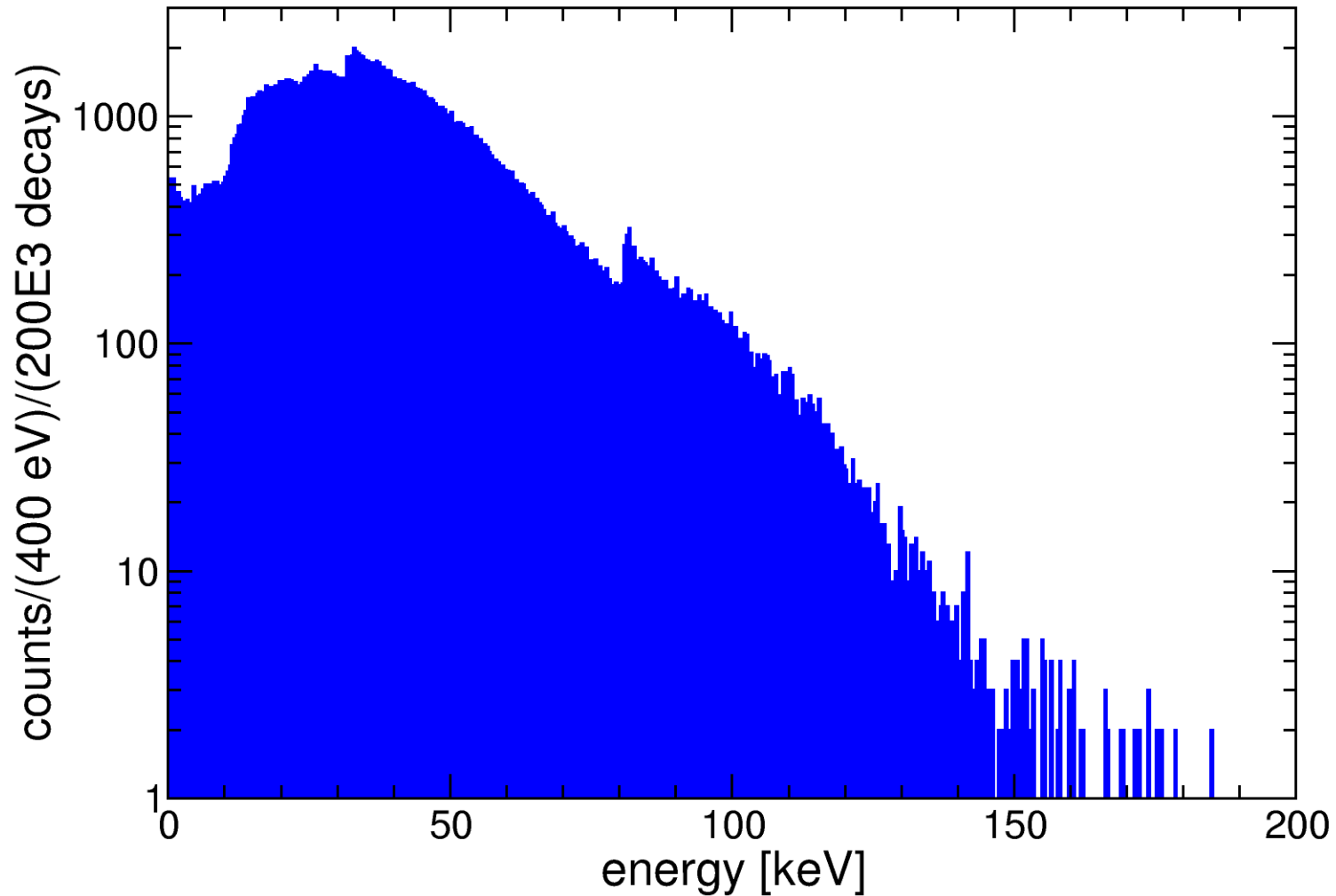
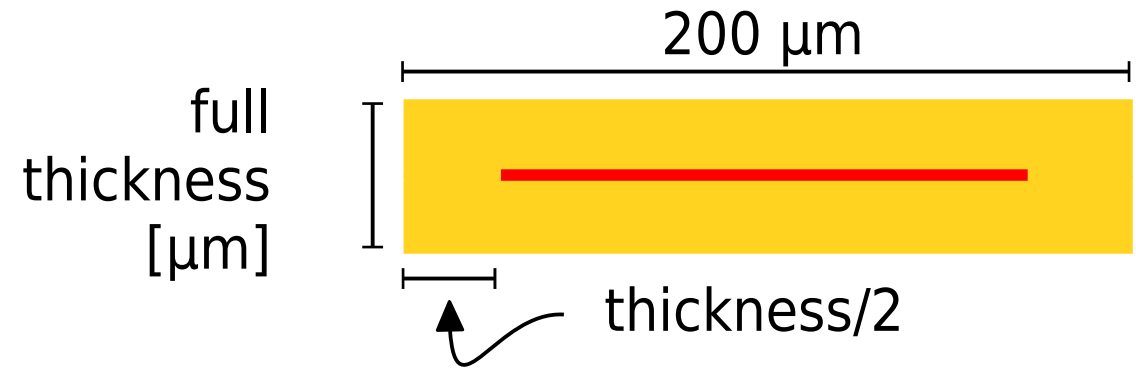
Low energy background: γ sources

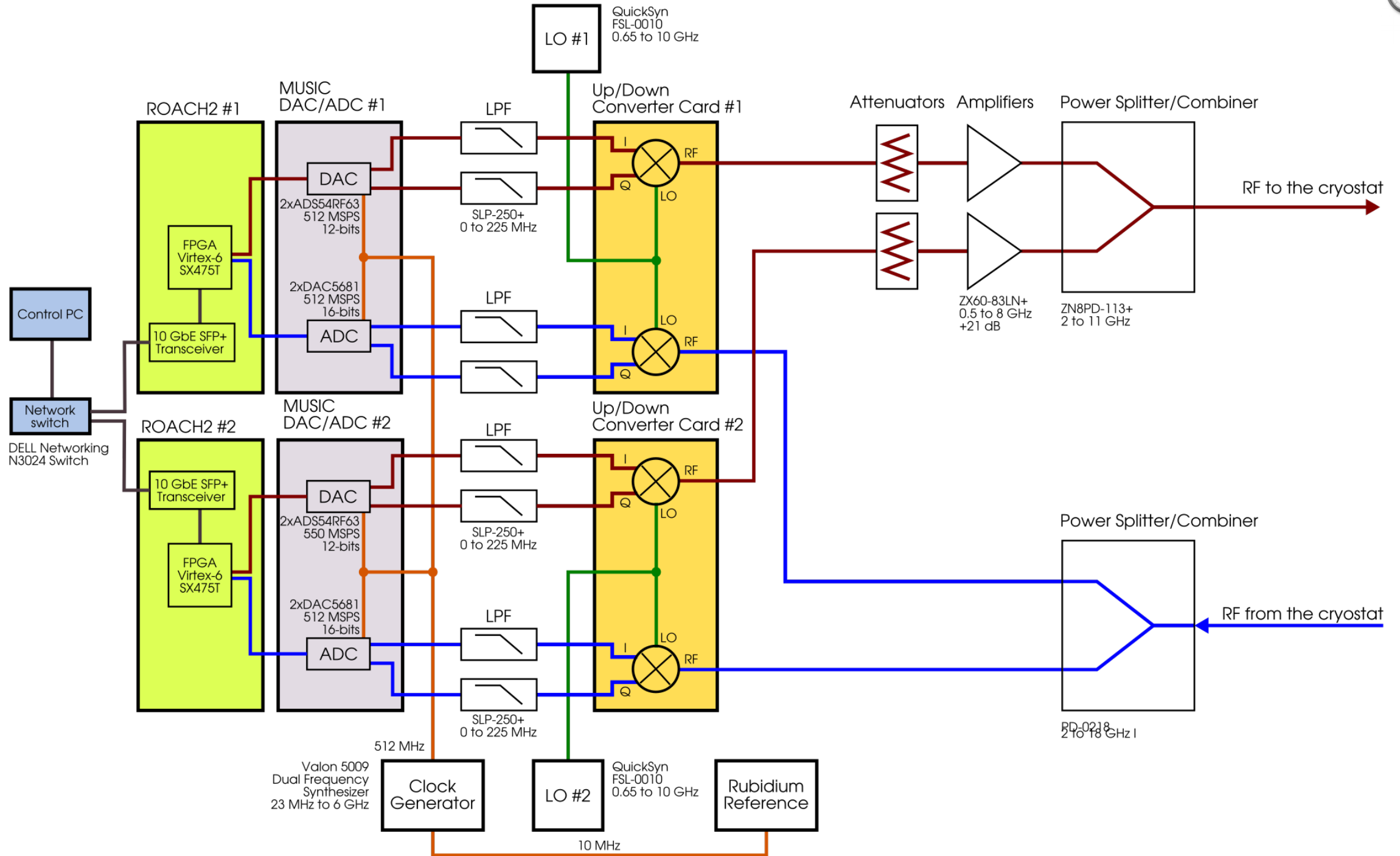


^{166m}Ho background



Geant4 + LowEnergyEM
 $2 \cdot 10^5$ events



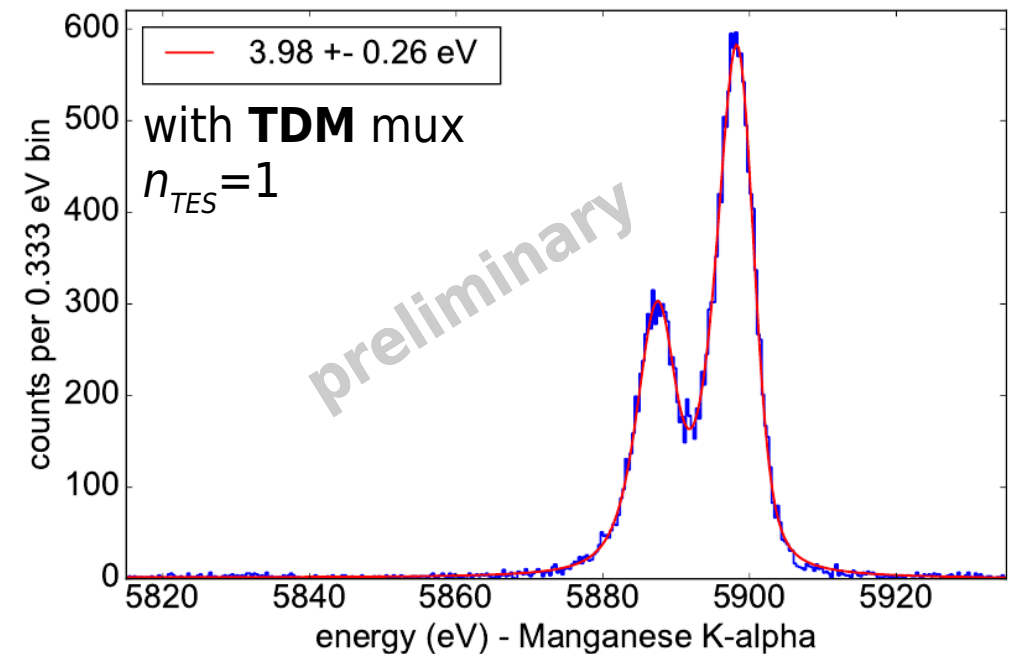
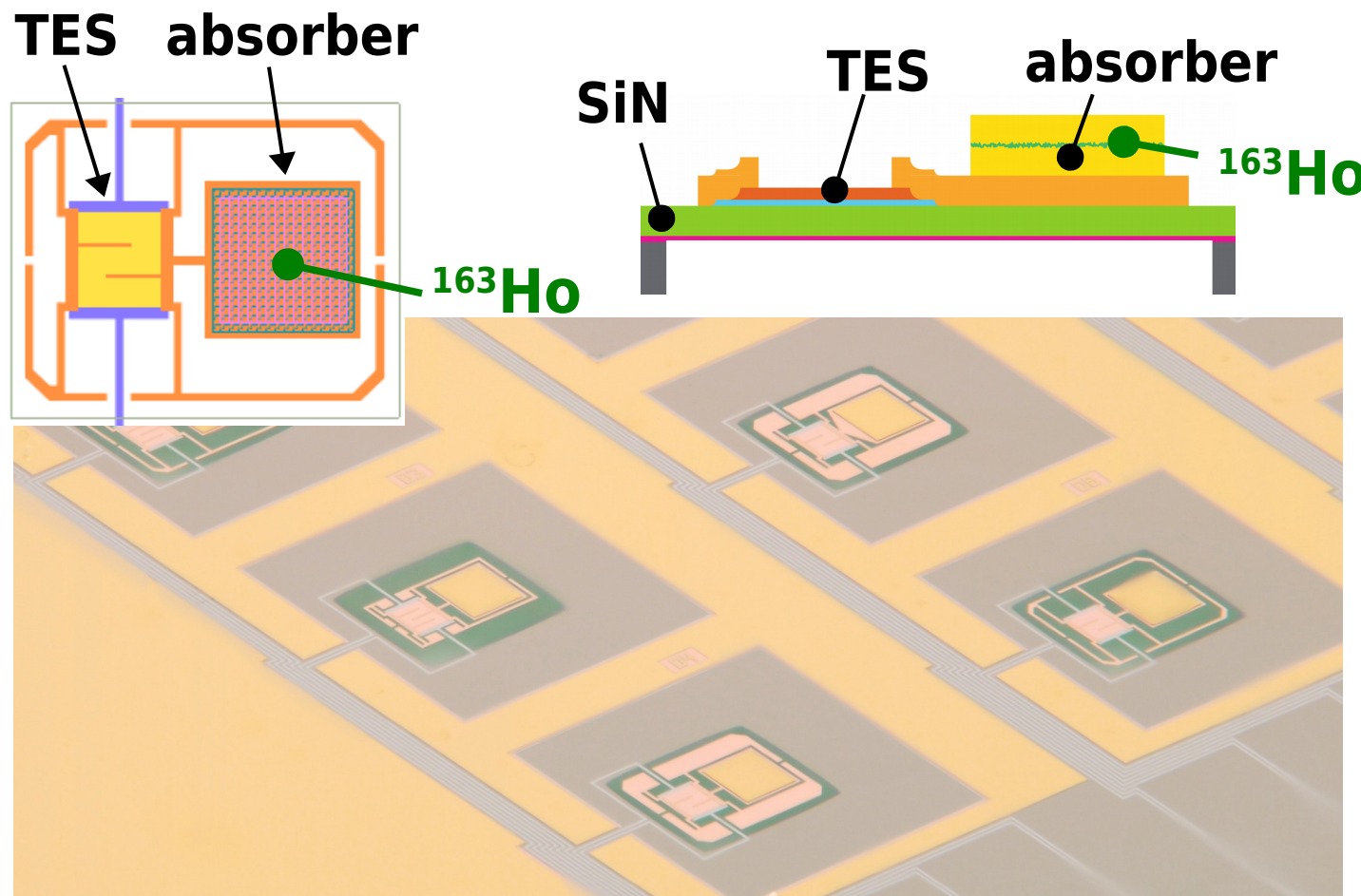


HOLMES pixel design and test



- optimize design for speed and resolution
 - ▷ **specs @3keV** : $\Delta E_{FWHM} \approx 1\text{eV}$, $\tau_{rise} \approx 10\mu\text{s}$, $\tau_{decay} \approx 100\mu\text{s}$
- **2 $\mu\text{m Au}$** thickness for *full* electron and photon absorption
- **side-car** design to avoid TES proximitation and G engineering for τ_{decay} control

TES prototypes w/o ^{163}Ho : fabrication & test @ NIST



- ▷ $\Delta E_{FWHM} \lesssim 4\text{ eV}$ @ 6 keV ($\rightarrow \approx 3\text{ eV}$ @ Q_{EC})
- ▷ $\tau_{rise} \approx 6\text{ }\mu\text{s}$ (with $L=38\text{ nH}$ \rightarrow to be slowed)
- ▷ $\tau_{decay} \approx 130\text{ }\mu\text{s}$ (still tunable)